

# STIC Search Report

# STIC Database Tracking triumine

TO: Gregg Cantelmo Location: REM 6C81

Art Unit : 1745 January 25, 2007

Case Serial Number: 10/766385

From: Mei Huang Location: EIC 1700 REMSEN 4B28

Phone: 571/272-3952 Mei.huang@uspto.gov

## Search Notes

Examiner Cantelmo,

Please feel free to contact me if you have any questions or if you would like to refine the search query,

Thank you for using STIC services!

Mei Huang



Banks, Kendra

From:

GREGG CANTELMO [gregg.cantelmo@uspto.gov]

Sent:

Wednesday, January 24, 2007 1:40 PM

To:

STIC-EIC1700

Subject:

Database Search Request, Serial Number: 10/766385

Requester:

GREGG CANTELMO (P/1745)

Art Unit:

GROUP ART UNIT 1745

Employee Number:

75777

Office Location:

REM 06C81

Phone Number:

(571)272-1283

Mailbox Number:

REM 6C81

SCIENTIFIC REFERENCE BR Sci & rech Inf - Cnt

JAN 2.4 RECD

Pat. & T.M Office

Case serial number:

10/766385

Class / Subclass(es):

Earliest Priority Filing Date:

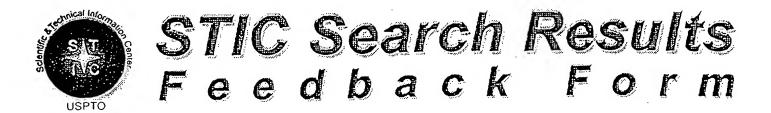
Format preferred for results:

Paper

Search Topic Information:

Please search the composite structure of claims 1-19. Note that the specification gives more detail with respect to the various material such as those materials recognized as suitable dopants.

Special Instructions and Other Comments:



		CHARLES .	14413	20042
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# -		# <b>.</b> # .	`_`	

Questions about the scope or the results of the search? Contact the EIC searcher or contact:

Kathleen Fuller, EIC 1700 Team Leader 571/272-2505 REMSEN 4B28

Voluntary Results Feedback Form
<ul> <li>I am an examiner in Workgroup: Example: 1713</li> <li>Relevant prior art found, search results used as follows:</li> </ul>
102 rejection
103 rejection
Cited as being of interest.
Helped examiner better understand the invention.
Helped examiner better understand the state of the art in their technology.
Types of relevant prior art found:
Foreign Patent(s)
<ul> <li>Non-Patent Literature</li> <li>(journal articles, conference proceedings, new product announcements etc.)</li> </ul>
> Relevant prior art not found:
Results verified the lack of relevant prior art (helped determine patentability).
Results were not useful in determining patentability or understanding the invention.
Comments:

.=> fil req FILE 'REGISTRY' ENTERED AT 13:21:29 ON 25 JAN 2007 USE IS SUBJECT TO THE TERMS OF YOUR STN CUSTOMER AGREEMENT. PLEASE SEE "HELP USAGETERMS" FOR DETAILS. COPYRIGHT (C) 2007 American Chemical Society (ACS)

#### => d his nofile

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(FILE 'HOME' ENTERED AT 10:43:07 ON 25 JAN 2007)
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FILE 'HCAPLUS' ENTERED AT 10:43:17 ON 25 JAN 2007 1 SEA US2004185343/PN L1

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FILE 'REGISTRY' ENTERED AT 10:44:32 ON 25 JAN 2007
L2
             11 SEA (10124-54-6/BI OR 10402-24-1/BI OR 14542-94-0/BI OR
          15885 SEA 7664-38-2/CRN
L3
           7585 SEA L3 AND M/ELS
L4
            609 SEA L4 AND 2/NC
L5
L6
            558 SEA L5 AND SALT#
L7
             51 SEA L5 NOT L6
              3 SEA L2 AND L5
L8
              1 SEA 7664-41-7/RN
L9
            217 SEA L5 AND (T1 OR T2 OR T3 OR B2)/PG
L10
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FILE 'HCAPLUS' ENTERED AT 11:22:48 ON 25 JAN 2007 84474 SEA L5 L11 14536 SEA L10 L12 1498 SEA L8 L13 L14 147983 SEA L9 257309 SEA NITRIDE# L15

11397 SEA OXYNITRIDE# L16 875 SEA L11 AND (L15 OR L16) L17 13515 SEA METAL? (2A) L15 L18 426 SEA METAL? (2A) L16 L19 L20 41 SEA L11 AND (L18 OR L19)

> FILE 'REGISTRY' ENTERED AT 11:33:19 ON 25 JAN 2007 1825625 SEA (M(L)N)/ELS 3082 SEA L21 (L) 2/ELC.SUB 2268 SEA L21 (L) O/ELS (L) 3/ELC.SUB 2071 SEA L22 AND (T1 OR T2 OR T3 OR B2)/PG

1416 SEA L23 AND (T1 OR T2 OR T3 OR B2)/PG FILE 'HCAPLUS' ENTERED AT 11:35:25 ON 25 JAN 2007

116903 SEA L22 L26 L27 8158 SEA L23

L22

L23

L24

L25

639 SEA L11 AND (L26 OR L27) L28

QUE MIXT# OR MIXTURE? OR BLEND? OR ADMIX? OR COMMIX? OR L29 IMMIX? OR INTERMIX? OR IMPREGNAT? OR COMPOSIT? OR COMPN# , OR COMPSN# OR FORMULAT? OR COMBINAT? OR INTERSPER? OR AMALGAM?

QUE DOPE# OR DOPING# OR DOPANT# L30

L31 249 SEA L28 AND L29

QUE (MIXT# OR MIXTURE? OR BLEND? OR ADMIX? OR COMMIX? OR L32 IMMIX? OR INTERMIX? OR COMPOSIT? OR COMPN# OR COMPSN# OR FORMULAT? OR INTERSPER?)/TI

L33 89 SEA L31 AND L32

L34 QUE (FIRST? OR 1ST OR 1(W)ST OR PRIMARY OR PRINCIPAL) (2A)

```
(COMPONENT? OR PART# OR PORTION? OR SEGMENT?)
L35
              0 SEA L33 AND L34
                D KWIC 1-5
                D KWIC L33 1-5
         380204 SEA NH3 OR AMMONIA#
L36
L37
             43 SEA L11 AND (NITRIDING# OR DITRIDED? OR NITRIDIZATION?)
L38
             10 SEA L11 AND (NITRIDING# OR NITRIDED# OR NITRIDIZATION?)
                AND (OXIDI? OR OXIDA? OR OXIDN#)
L39
            124 SEA L11 AND OXYNITRIDING# OR OXYNITRIDED# OR OXYNITRIDIZA
                TION?
L40
             68 SEA (L37 OR L38 OR L39 OR L20) AND L29
L41
                QUE COMPOSITE#
L42
             18 SEA L40 AND L41
L43
             7 SEA (L37 OR L38 OR L39 OR L20) AND L30
                QUE MILLING? OR MILL OR MILLS OR MILLED OR BALLMILL? OR
L44
                BALL(W)MILL? OR CRUMBL? OR GRIND? OR CRUSH?
             6 SEA (L40 OR L42 OR L43) AND L44
L45
                QUE CORE? OR KERNEL? OR SHELL?
L46
L47
                QUE ENCAPSUL? OR CAPSULAT?
L48 '
             3 SEA (L40 OR L42 OR L43) AND (L46 OR L47)
            19 SEA (L40 OR L42 OR L43) AND (L14 OR L36)
L49
            32 SEA L33 AND L41
L50
             1 SEA L50 AND (L46 OR L47)
L51
            27 SEA L42 OR L43 OR L45 OR L48
L52
            44 SEA L40 NOT L52
L53
            18 SEA L52 AND L41
L54:
             0 SEA L53 AND L41
L55
            18 SEA L51 OR L54
L56
L57
             9 SEA L52 NOT L56
L58
               QUE OLIVINE? OR NASICON?
            3 SEA (L40 OR L42 OR L43) AND L58
L59
            18 SEA L59 OR L56
L60
             2 SEA L50 AND L58
L61
L62
            18 SEA L61 OR L56
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## => fil hcap

FILE 'HCAPLUS' ENTERED AT 13:21:32 ON 25 JAN 2007 USE IS SUBJECT TO THE TERMS OF YOUR STN CUSTOMER AGREEMENT. PLEASE SEE "HELP USAGETERMS" FOR DETAILS. COPYRIGHT (C) 2007 AMERICAN CHEMICAL SOCIETY (ACS)

#### => d 156 ibib abs hitstr hitind 1-18

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L56 ANSWER 1 OF 18 HCAPLUS COPYRIGHT 2007 ACS on STN
ACCESSION NUMBER:
                        2006:1223102 HCAPLUS
TITLE:
                        Microstructure of the composite
                        oxynitrided chromium layers produced on
                         steel by a duplex method
AUTHOR (S):
                        Tacikowski, M.; Ulbin-Pokorska, I.; Wierzchon,
CORPORATE SOURCE:
                        Faculty of Materials Science and Engineering,
                        Warsaw University of Technology, Warsaw, 02-507,
                        Pol.
SOURCE:
                        Surface and Coatings Technology (2006), 201(6),
                        2776-2781
                        CODEN: SCTEEJ; ISSN: 0257-8972
```

PUBLISHER: Elsevier B.V.

DOCUMENT TYPE: Journal LANGUAGE: English

AB The paper describes the microstructure of the composite layers produced on chromium pre-coated AISI 1045 steel by oxynitriding under glow discharge conditions (duplex method). The layers were examined by the cross-section method using transmission electron microscopy. Their microstructure was composed of the 4 zones: a near-surface CrN-Cr203 mixture zone about 1 μm thick, a Cr2N zone about 4 μm thick, a chromium zone-the thickest-about 50 μm, and the thinnest (Cr,Fe)7C3 zone about 0.5 μm thick. Cr203 also occurred in the form of nano-crystalline aggregates, about 1 μm in size, situated in the upper part of the Cr2N zone. All the zones had a fine-grained structure, except the finest nano-crystalline zone situated at the surface. It was found that, during oxynitriding, the cracks present in the chromium coating are filled up by chromium nitrides and oxides. This may explain the observed improvement of the corrosion resistance.

CC 55 (Ferrous Metals and Alloys)

REFERENCE COUNT: 18 THERE ARE 18 CITED REFERENCES AVAILABLE

FOR THIS RECORD. ALL CITATIONS AVAILABLE

IN THE RE FORMAT

L56 ANSWER 2 OF 18 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER:

2006:337615 HCAPLUS

DOCUMENT NUMBER: TITLE:

144:394637 Solid electrolytes based on lithium hafnium

phosphate for active metal anode protection

INVENTOR(S):

Nimon, Yevgeniy S.; De Jonghe, Lutgard C.;

Visco, Steven J.

PATENT ASSIGNEE(S):

Polyplus Battery Company, USA U.S. Pat. Appl. Publ., 16 pp.

CODEN: USXXCO

DOCUMENT TYPE:

Patent

LANGUAGE:

SOURCE:

English

FAMILY ACC. NUM. COUNT: 1

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
US 2006078790	A1	20060413	US 2005-245472	
				200510
DDIODIMU ADDIN TWO			VIO 0004 61600ED D	05
PRIORITY APPLN. INFO.:			US 2004-616325P P	

200410

AB Active metal electrochem. structure, in particular an active metal neg. electrode (anode) protected with an ionically conductive protective architecture incorporating a glassy, ceramic or glass-ceramic solid electrolyte material based on lithium hafnium phosphate, and associated electrochem. devices and methods, provides advantages over conventional structures. The protective architecture prevents the active metal from deleterious reaction with the environment on the other (cathode) side of the architecture, which may include aqueous, air or organic liquid electrolytes and/or electrochem. active materials.

IT 10377-52-3, Lithium phosphate

RL: DEV (Device component use); USES (Uses)

(can be in conductive glass or ceramic electrolyte material; solid electrolytes based on lithium hafnium phosphate for active metal anode protection)

RN 10377-52-3 HCAPLUS

CN Phosphoric acid, trilithium salt (8CI, 9CI) (CA INDEX NAME)

#### •3 Li

INCL 429137000; 429246000; 429303000

CC 52-2 (Electrochemical, Radiational, and Thermal Energy Technology)

Section cross-reference(s): 72

IT Membranes, nonbiological

(composite, semipermeable; solid electrolytes based on

lithium hafnium phosphate for active metal anode protection)

IT Glass, uses

RL: DEV (Device component use); TEM (Technical or engineered

material use); USES (Uses)

(oxynitride, active metal phosphorus

oxynitride glass, conductive, contacts anode; solid

electrolytes based on lithium hafnium phosphate for active metal anode protection)

IT Battery electrolytes

Calcination

Cathodic protection

Ceramics

Glass ceramics

Grinding (size reduction)

Primary batteries

Primary battery separators

Secondary batteries

Secondary battery separators

(solid electrolytes based on lithium hafnium phosphate for active

metal anode protection)

IT 7439-93-2D, Lithium, inorg. compds. 10377-52-3, Lithium

phosphate 12057-24-8, Lithium oxide, uses 13774-56-6

RL: DEV (Device component use); USES (Uses)

(can be in conductive glass or ceramic electrolyte material; solid electrolytes based on lithium hafnium phosphate for active metal and a protection)

metal anode protection)

L56 ANSWER 3 OF 18 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER:

2005:119884 HCAPLUS

DOCUMENT NUMBER:

142:204864

TITLE:

Medical implants coated with porous carbon

surfaces carrying drugs

INVENTOR(S): PATENT ASSIGNEE(S): Rathenow, Joerg; Asgari, Soheil; Ban, Andreas

Blue Membranes GmbH, Germany

SOURCE:

Ger. Offen., 15 pp.

CODEN: GWXXBX

DOCUMENT TYPE:

Patent

LANGUAGE:

German

FAMILY ACC. NUM. COUNT: 10

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
DE 10333099	A1	20050210	DE 2003-10333099	200307
DE 202004009061	U1	20040916	DE 2004-202004009061	21 200405
AU 2004243503	<b>A1</b>	20041209	AU 2004-243503	28 200405
CA 2519750	A1	20041209	CA 2004-2519750	28
WO 2004105826	A2	20041209	WO 2004-EP5785	28 200405
CH, CN, CO, GB, GD, GE, KR, KZ, LC, MX, MZ, NA, SE, SG, SK, VC, VN, YU, RW: BW, GH, GM, AM, AZ, BY, DE, DK, EE, PT, RO, SE, GW, ML, MR, EP 1626749  R: AT, BE, CH, PT, IE, SI,	AM, AT CR, CU GH, GM LK, LR NI, NO SL, SY ZA, ZM KE, LS KG, KZ ES, FI SI, SK NE, SN A2 DE, DK LT, LV	, CZ, DE, D , HR, HU, I , LS, LT, L , NZ, OM, P , TJ, TM, T , ZW , MW, MZ, N , MD, RU, T , FR, GB, G , TR, BF, B , TD, TG 20060222	A, BB, BG, BR, BW, BY, BK, DM, DZ, EC, EE, EG, D, IL, IN, IS, JP, KE, D, LV, MA, MD, MG, MK, BG, PH, PL, PT, RO, RU, TN, TR, TT, TZ, UA, UG, TA, SD, SL, SZ, TZ, UG, TJ, TM, AT, BE, BG, CH, BR, HU, IE, IT, LU, MC, DJ, CF, CG, CI, CM, GA, EP 2004-735213  BB, GR, IT, LI, LU, NL, BR, 2004-10957	28 BZ, CA, ES, FI, KG, KP, MN, MW, SC, SD, US, UZ, ZM, ZW, CY, CZ, NL, PL, GN, GQ,  200405 28 SE, MC,
US 2005079201	A1	20050414	US 2004-939021	28
PRIORITY APPLN. INFO.:			DE 2003-10324415 A	10 1 200305 28
			DE 2003-10333098 A	1 200307 21
			DE 2003-10333099 A	1 200307 21
			WO 2004-EP5785 W	200405

The invention concerns a method for the preparation of medical implants AB with functionalized surfaces involving the steps: (a) preparation of medical implant that is at least partially coated with a carbon-containing layer; (b) activation of the carbon-containing layer by forming a pores on the surface; (c) functionalization of the activated, carbon-containing surface. The carbon-containing layer is composed of pyrolytically prepared carbon, carbon deposited by CVD or PVD process, sputtered carbon, metal carbides, metal carbonitrides, metal oxynitrides, metal oxycarbides or their combinations. The carbon-containing layers are activated by oxidation with air, oxygen, dinitrogen oxide, and oxidizing acids, also at elevated temperature A reduction process can also be used for activation. Activated surfaces are functionalized by loading one or more drugs, microorganisms or cells onto the surface. Activated surfaces can be sealed in a CVD or CVI (chemical vapor infiltration) process. The implants are prepared from carbon, carbon fibers, ceramics, glass, metals, alloys, artificial bone, stone, minerals. Artificial blood vessels, stents, coronary stents, peripheral stents, orthopedic implants, bone and joint prosthesis, artificial heart, heart valves, s.c., and i.m. implants can be activated and functionalized.

IT 7758-87-4, Tricalciumphosphate

RL: THU (Therapeutic use); BIOL (Biological study); USES (Uses) (medical implants coated with porous carbon surfaces carrying drugs)

RN 7758-87-4 HCAPLUS

CN Phosphoric acid, calcium salt (2:3) (9CI) (CA INDEX NAME)

●3/2 Ca

IC ICM A61L027-00

ICS A61L029-00; A61L033-00; A61F002-30; A61F002-28; A61F002-44; A61F002-24

CC 63-7 (Pharmaceuticals)

IT Composites

(carbon composites; medical implants coated with porous carbon surfaces carrying drugs)

IT Carbonitrides

RL: THU (Therapeutic use); BIOL (Biological study); USES (Uses) (metal carbide nitrides; medical implants

coated with porous carbon surfaces carrying drugs)

IT Oxynitrides

RL: THU (Therapeutic use); BIOL (Biological study); USES (Uses) (metal oxynitrides; medical implants coated with porous carbon surfaces carrying drugs)

IT 50-02-2, Dexamethasone 50-07-7, Mitomycin 50-23-7, Hydrocortisone 50-24-8, Prednisolone 50-56-6, Oxytocin, biological studies 50-78-2, Acetylsalicylic acid 51-41-2,

Norepinephrine 51-43-4, Epinephrine 51-45-6, Histamine, 51-61-6, Dopamine, biological studies biological studies 53-03-2, Prednisone 53-06-5, Cortisone 52-53-9, Verapamil 53-86-1, Indomethacin 54-05-7, Chloroquine 56-23-5, Carbon 56-54-2, Quinidine tetrachloride, biological studies Chloramphenicol 57-22-7, Vincristin 57-41-0, Phenytoine 58-61-7, Adenosine, biological studies 58-14-0, Pyrimethamin 59-05-2, Methotrexate 59-30-3, Folic acid, biological studies 61-33-6, Penicillin G, biological studies 60-54-8, Tetracycline 61-68-7, Mefenamic acid 62-55-5, Thioacetamide 63-74-1, Sulfonamide 64-17-5, Ethanol, biological studies 68-35-9, azine 69-53-4, Ampicillin 71-63-6, Digitoxin 80 83-43-2, Methylprednisolone 87-08-1, Penicillin V Sulfadiazine 80-08-0, 114-07-8, Erythromycin 118-42-3, Hydroxychloroquine 119-04-0. 124-94-7, Triamcinolone 127-07-1, Hydroxycarbamide Framycetin 137-58-6, Lidocaine 127-31-1, Fludrocortisone 140-64-7, Pentamidine diisethionate 152-47-6, Sulfalene 154-21-2, 302-79-4, Tretinoin 356-12-7, Fluocinonide Lincomycin 365-26-4, Oxilofrine 370-14-9, Pholedrine 378-44-9, Betamethasone 382-67-2, Desoximetasone 443-48-1, Metronidazol 500-92-5, 466-06-8, Proscillaridin 484-23-1, Dihydralazin Proquanil 511-12-6, Dihydroergotamine 525-66-6, Propranolol 536-21-0, Norfenefrine 552-94-3, Salsalate 555-30-6, Methyldopa 564-25-0, Doxycycline 586-06-1, Orciprenaline 630-60-4, Ouabain 638-94-8, Desonide 644-62-2 660-27-5, Diisopropyl amine dichloroacetate 709-55-7, Etilefrine 738-70-5, Trimethoprim 768-94-5, Amantadine 807-38-5, Fluocinolone 865-21-4, Vinblastin 1066-17-7, Colistin 1306-05-4, Fluorapatite 1306-06-5, 1393-87-9, Fusafungine Hydroxylapatite 1404-26-8, Polymyxin B 1404-90-6, Vancomycin 1524-88-5, Flurandrenolide 1695-77-8, Spectinomycin 1951-25-3, Amiodarone 2589-47-1, Prajmaliumbitartrate, biological studies 2809-21-4, Etidronic acid 3056-17-5, Stavudine 3093-35-4, Halcinonide 3385-03-3, 3737-09-5, Disopyramide Flunisolide 3930-20-9, Sotalol 4360-12-7, Ajmalin 4419-39-0, Beclomethasone 4828-27-7, 5104-49-4, Flurbiprofen 4936-47-4, Nifuratel Clocortolone 6452-71-7, Oxprenolol 5355-48-6 6990-06-3, Fusidinic acid 7440-22-4, Silver, biological studies 7440-25-7, Tantalum, biological studies 7440-32-6, Titanium, biological studies 7440-66-6, Zinc, biological studies 7481-89-2, Zalcitabine 7542-37-2, Paromomycin 7681-49-4, Sodium fluoride, biological studies 7758-87-4, Tricalciumphosphate 8001-27-2, 8025-81-8, Spiramycin 8067-24-1, Co-Dergocrine mesylate Hirudin 9000-07-1, Carrageenan 9002-01-1, Streptokinase 9002-60-2, Corticotropin, biological studies 9002-71-5, Thyrotrophin 9002-88-4, Polyethylene 9002-89-5, Polyvinylalcohol Acrylic acid homopolymer 9003-07-0, Polypropylene 9003-39-8, Polyvinylpyrrolidone 9004-32-4, Carboxymethylcellulose 9004-34-6, Cellulose, biological studies 9004-54-0, Dextran, biological studies 9004-61-9, Hyaluronic acid 9004-64-2, Hydroxypropylcellulose 9004-65-3, Hydroxypropylmethylcellulose 9004-67-5, Methylcellulose 9005-25-8, Starch, biological studies 9005-32-7, Alginic acid 9005-49-6, Heparin, biological studies 9039-53-6, Urokinase 9061-61-4, Nerve growth 9012-76-4, Chitosan 10118-90-8, Minocycline 10163-15-2, Disodium fluorophosphate 10596-23-3, Clodronic acid 11096-26-7, 11111-12-9, Cephalosporin 11128-99-7, Angiotensin Erythropoietin 12597-68-1, Stainless steel, biological studies 12629-01-5, Somatropin 12683-48-6 13010-20-3, Nitrosourea 13292-46-1, 13463-67-7, Titanium dioxide, biological studies Rifampicin

```
14402-89-2, Nitroprusside sodium
                                  14636-12-5, Terlipressin
15307-86-5, Diclofenac 15663-27-1, Cisplatin
                                               15686-71-2,
           15687-27-1, Ibuprofen 16662-47-8, Gallopamil
Cefalexin
16679-58-6, Desmopressin 16846-24-5, Josamycin 18323-44-9,
Clindamycin 19216-56-9, Prazosin
                                  19387-91-8, Tinidazol
19388-87-5, Taurolidine
                         20830-75-5, Digoxin
                                             21256-18-8,
           21829-25-4, Nifedipine
                                  22071-15-4, Ketoprofen
Oxaprozin
22204-53-1, Naproxen 22254-24-6, Ipratropium bromide
                                                       22494-42-4,
Diflunisal
            23155-02-4, Fosfomycin 24937-78-8
                                                25038-59-9,
biological studies 25087-26-7, Methacrylic acid homopolymer
                      25122-41-2, Clobetasol 25190-06-1,
25104-18-1, Polylysine
Poly(Tetramethylene glycol) 25322-68-3, Polyethylene oxide
25322-69-4, Polypropylene oxide
                                25614-03-3, Bromocriptine
25953-19-9, Cefazolin 26009-03-0, Polyglycolic acid
                                                      26023-30-3,
Poly[oxy(1-methyl-2-oxo-1,2-ethanediyl)] 26063-00-3,
β-Hydroxybutyric acid homopolymer 26099-09-2
                                               26100-51-6,
Polylactic acid 26124-68-5, Polyglycolic acid
                                                26171-23-3,
          26744-04-7, β-Hydroxybutyric acid homopolymer, sru
26787-78-0, Amoxicillin 26807-65-8, Indapamide
                                                26844-12-2,
Indóramin
           29122-68-7, Atenolol
                                 29679-58-1, Fénoprofen
30209-88-2, Polyallyl cyanoacrylate
                                    30516-87-1, Zidovudine
30578-37-1, Amezinium metil sulfate
                                    30685-43-9, Metildigoxin
31621-87-1, Polydioxanone
                         31828-71-4, Mexiletine
                                                   33069-62-4,
           33515-09-2, Gonadorelin 33774-52-6,
Paclitaxel
Detajmiumbitartrate, biological studies
                                       34346-01-5, Lactic
acid-glycolic acid copolymer 34661-75-1, Urapidil
                                                    35607-66-0,
           36322-90-4, Piroxicam
                                  36703-88-5
Cefoxitin
                                             36791-04-5,
                                 38304-91-5, Minoxidil
           38194-50-2, Sulindac
Ribavirin
39562-70-4, Nitrendipine 40391-99-9
                                     41340-25-4, Etodolac
41575-94-4, Carboplatin 41708-72-9, Tocainide 42399-41-7,
          42794-76-3, Midodrine 42924-53-8, Nabumetone
Diltiazem
50370-12-2, Cefadroxil 50972-17-3, Bacampicillin 51022-69-6,
            51110-01-1, Somatostatin 51264-14-3, Amsacrine
Amcinonide
51333-22-3, Budesonide
                      51384-51-1, Metoprolol 51481-65-3,
            51940-44-4, Pipemidic acid 52013-44-2, Nitinol
Mezlocillin
53123-88-9, Sirolimus 53230-10-7, Mefloquine 53237-50-6
53714-56-0, Leuprorelin 53910-25-1, Pentostatin
                                                 53994-73-3,
         54063-53-5, Propafenone 54143-55-4, Flecainide
Cefaclor
54143-56-5, Flecainide acetate 55142-85-3, Ticlopidine
55268-75-2, Cefuroxim 56391-56-1, Netilmicin 57773-63-4,
Triptorelin
            57982-77-1, Buserelin
                                    58066-85-6, Miltefosine
59277-89-3, Aciclovir
RL: THU (Therapeutic use); BIOL (Biological study); USES (Uses)
   (medical implants coated with porous carbon surfaces carrying
   drugs)
```

```
L56 ANSWER 4 OF 18 HCAPLUS COPYRIGHT 2007 ACS on STN
ACCESSION NUMBER:
                         2005:13257 HCAPLUS
DOCUMENT NUMBER:
                         142:80039
TITLE:
                         Implant materials containing metals and calcium
                         phosphate ceramics, and their manufacture
INVENTOR (S):
                         Inagaki, Masahiko; Kameyama, Tetsuya; Hasegawa,
                         Koji
PATENT ASSIGNEE(S):
                         National Institute of Advanced Industrial
                         Science and Technology, Japan
SOURCE:
                         Jpn. Kokai Tokkyo Koho, 11 pp.
                         CODEN: JKXXAF
DOCUMENT TYPE:
                         Patent
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LANGUAGE: Japanese

FAMILY ACC. NUM. COUNT: 1

#### PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
JP 2005000519	Α	20050106	JP 2003-169524	
				200306
US 2005161120	A1	20050728	US 2004-866132	13
			02 2001 000102	200406
				14
PRIORITY APPLN. INFO.:			JP 2003-169524 A	200206
				200306 13

AB The implant materials are manufactured by mixing metal powders which have thermal expansion coeffs. similar to those of substrates with Ca phosphate-based ceramics at arbitrary ratios, changing the mixing ratios so that the ratios of the metal powders become higher at the substrate side, forming films having gradient structures by using the powder mixts., and nitriding the metals during forming the gradient structures to form nitride layers in the metals. The implant materials show low residual strain, increased bond strength and stability of the films, and good initial fixation onto the bone. A 150-µm film was formed onto a Ti alloy substrate by plasma spraying of Ti-hydroxyapatite mixts. by changing their mixing ratios at 100:0, 70:30, 40:60, and 0:100, while introducing N to the plasma during film forming for nitriding. The adhesive strength between the substrate and the film was .apprx.50 MPa. A Ti rod was plasma-sprayed with apatite-Ti mixts. to give a test piece, which was implanted into the femur of a dog. The pull strength of the implanted test piece from the femur was .apprx.14.4 MPa 4 wk after implantation.

10103-46-5, Calcium phosphate
RL: DEV (Device component use); PEP (Physical, engineering or

chemical process); PYP (Physical process); THU (Therapeutic use); BIOL (Biological study); PROC (Process); USES (Uses)

(bone implant materials having films of composition-gradient nitrided metal/calcium phosphate ceramics

mixts. with good adhesion to metal substrates)

RN 10103-46-5 HCAPLUS

CN Phosphoric acid, calcium salt (8CI, 9CI) (CA INDEX NAME)

#### ●x Ca

IC ICM A61L027-00

CC 63-7 (Pharmaceuticals)

Section cross-reference(s): 56, 57

ST metal calcium phosphate ceramic bone implant; titanium

```
nitriding hydroxyapatite ceramic bone implant
IT
     Bone
        (artificial; bone implant materials having films of compn
        .-gradient nitrided metal/calcium phosphate
        ceramics mixts. with good adhesion to metal substrates)
IT
     Ceramic composites
     Ceramics
     Metal matrix composites
       Nitriding
        (bone implant materials having films of composition-gradient
        nitrided metal/calcium phosphate ceramics
        mixts. with good adhesion to metal substrates)
IT
     Metals, biological studies
     RL: CPS (Chemical process); DEV (Device component use); PEP
     (Physical, engineering or chemical process); PYP (Physical process);
     THU (Therapeutic use); BIOL (Biological study); PROC (Process); USES
     (Uses)
        (bone implant materials having films of composition-gradient
        nitrided metal/calcium phosphate ceramics
        mixts. with good adhesion to metal substrates)
IT
     Nitrides
     RL: DEV (Device component use); FMU (Formation, unclassified); THU
     (Therapeutic use); BIOL (Biological study); FORM (Formation,
     nonpreparative); USES (Uses)
        (bone implant materials having films of composition-gradient
        nitrided metal/calcium phosphate ceramics
        mixts. with good adhesion to metal substrates)
ΙT
     Prosthetic materials and Prosthetics
        (implants; bone implant materials having films of compn
        .-gradient nitrided metal/calcium phosphate
        ceramics mixts. with good adhesion to metal substrates)
IT
     Coating process
        (plasma spraying; bone implant materials having films of
        composition-gradient nitrided metal
        /calcium phosphate ceramics mixts. with good adhesion
        to metal substrates)
IT
     Titanium alloy, base
     RL: DEV (Device component use); THU (Therapeutic use); BIOL
     (Biological study); USES (Uses)
        (substrate; bone implant materials having films of compn
        .-gradient nitrided metal/calcium phosphate
        ceramics mixts. with good adhesion to metal substrates)
IT
     7440-32-6, Titanium, biological studies
     RL: CPS (Chemical process); DEV (Device component use); PEP
     (Physical, engineering or chemical process); PYP (Physical process);
     THU (Therapeutic use); BIOL (Biological study); PROC (Process); USES
     (Uses)
        (bone implant materials having films of composition-gradient
        nitrided metal/calcium phosphate ceramics
       mixts. with good adhesion to metal substrates)
IT
     25583-20-4, Titanium nitride
    RL: DEV (Device component use); FMU (Formation, unclassified); THU
     (Therapeutic use); BIOL (Biological study); FORM (Formation,
     nonpreparative); USES (Uses)
        (bone implant materials having films of composition-gradient
       nitrided metal/calcium phosphate ceramics
       mixts. with good adhesion to metal substrates)
IT
     1306-06-5, Hydroxyapatite 10103-46-5, Calcium phosphate
    RL: DEV (Device component use); PEP (Physical, engineering or
     chemical process); PYP (Physical process); THU (Therapeutic use);
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BIOL (Biological study); PROC (Process); USES (Uses)
(bone implant materials having films of composition-gradient nitrided metal/calcium phosphate ceramics
mixts. with good adhesion to metal substrates)

L56 ANSWER 5 OF 18 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER:

2004:1075078 HCAPLUS

DOCUMENT NUMBER:

142:417084

TITLE:

Fabrication of novel hydroxyapatite/titanium

composite coating using rf reactive

plasma spraying

AUTHOR(S):

Yokogawa, Y.; Inagaki, M.; Kameyama, T.

CORPORATE SOURCE:

Ceramic Research Institute, National Institute of Advanced Industrial Science and Technology,

Aichi, 463-8560, Japan

SOURCE:

Ceramic Engineering and Science Proceedings

(2004), 25(4), 555-564

CODEN: CESPDK; ISSN: 0196-6219

PUBLISHER: DOCUMENT TYPE:

American Ceramic Society

LANGUAGE:

Journal English

Novel hydroxyapatite (HAp) / titanium (Ti) functionally gradient AB composite material has been developed by new plasma spraying technique using radio-frequency (rf) thermal plasma spraying method. Plasma sprayed HAp coating on titanium substrate has been used for hip prostheses and dental implant, however, there is a in vivo problem of loosening. HAp coatings with sufficient thickness and excellent adhesion to the Ti substrate have been strongly demanded. The plasma-sprayed process is specified by the associated processing parameters (particle size of HAp powder, carrier gas rate, plasma power, and spraying time et al.) where these influence the properties of the resultant deposits. To improve the stability in vivo, the highly oriented HAp coatings were prepared by rf. thermal plasma method, and the degree of this orientation was little affected by RF input power while it showed a tendency to increase with an increase in the substrate temperature during spraying. To improve bond strength of HAp coatings to titanium substrate, the HAp/Ti functionally gradient composite coating on Ti substrates was successfully prepared The ratio of HA and Ti powders supplied into the plasma was precisely controlled by two micro-feeders so as to change the coating composition from Ti-rich to HA-rich toward the upper layer, and the thickness of HAp/Ti composite layer was 50  $\mu m$ . Above that, only HAp was applied to produce HAp layer 100 mm thick on the top. The bond strength between HAp layer and Ti substrate was remarkably improved. It was also found to be depended on the partial nitriding of Ti deposits using rf reactive plasma spraying. When sprayed with 1.8% N2 added at 27 kW, the bond strength of the obtained HA/Ti composite coatings reached 65.3 MPa. From the results of XRD and SEM anal., titanium nitrides were formed in the titanium deposits sprayed with plasma gas containing N2.

IT 7758-87-4, TCP

RL: FMU (Formation, unclassified); FORM (Formation, nonpreparative) (fabrication of novel hydroxyapatite/titanium composite coating using rf reactive plasma spraying)

RN 7758-87-4 HCAPLUS

CN Phosphoric acid, calcium salt (2:3) (9CI) (CA INDEX NAME)

#### ●3/2 Ca

CC 63-7 (Pharmaceuticals)

IT

(artificial; fabrication of novel hydroxyapatite/titanium composite coating using rf reactive plasma spraying)

IT Adhesion, physical

Nitriding

(fabrication of novel hydroxyapatite/titanium composite coating using rf reactive plasma spraying)

Prosthetic materials and Prosthetics IT

> (implants; fabrication of novel hydroxyapatite/titanium composite coating using rf reactive plasma spraying)

IT Coating process

> (plasma spraying; fabrication of novel hydroxyapatite/titanium composite coating using rf reactive plasma spraying)

7758-87-4, TCP IT

RL: FMU (Formation, unclassified); FORM (Formation, nonpreparative) (fabrication of novel hydroxyapatite/titanium composite coating using rf reactive plasma spraying)

1306-06-5, Hydroxyapatite 7440-32-6, Titanium, biological studies IT RL: PEP (Physical, engineering or chemical process); PYP (Physical process); THU (Therapeutic use); BIOL (Biological study); PROC (Process); USES (Uses)

> (fabrication of novel hydroxyapatite/titanium composite coating using rf reactive plasma spraying)

REFERENCE COUNT:

THERE ARE 23 CITED REFERENCES AVAILABLE 23 FOR THIS RECORD. ALL CITATIONS AVAILABLE IN THE RE FORMAT

L56 ANSWER 6 OF 18 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER:

2004:650265 HCAPLUS

DOCUMENT NUMBER:

141:159883

TITLE:

Composite material and electrodes made therefrom for lithium battery cathode

INVENTOR(S):

Wang, Liya; Xu, Chuanjing; Miller, John M.

PATENT ASSIGNEE(S):

T/J Technologies, Inc., USA

SOURCE:

PCT Int. Appl., 16 pp.

DOCUMENT TYPE:

CODEN: PIXXD2 Patent

LANGUAGE:

English

FAMILY ACC. NUM. COUNT:

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
WO 2004068616	A2	20040812	WO 2004-US2470	200401

29

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WO 2004068616
                                    A3
                                             20041028
            W: AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NA, NI
      US 2004185343
                                             20040923
                                                              US 2004-766385
                                                                                               200401
      CA 2514957
                                    A1
                                             20040812
                                                              CA 2004-2514957
                                                                                               200401
      EP 1595306
                                    A2
                                             20051116
                                                              EP 2004-706469
                                                                                               200401
            R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC,
                  PT, IE, SI, LT, LV, FI, RO, MK, CY, AL, TR, BG, CZ, EE, HU,
                  SK
                                             20060706
      JP 2006516803
                                    Т
                                                              JP 2006-503129
                                                                                               200401
                                                                                               29
                                                              US 2003-443663P
PRIORITY APPLN. INFO.:
                                                                                               200301
                                                                                               30
                                                             US 2004-766385
                                                                                               200401
                                                                                               28
                                                              WO 2004-US2470
                                                                                               200401
                                                                                               29
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AB A composite material having utility as a cathode material for a lithium ion battery includes a first component which is a metal phosphate and a second component which is a metal nitride, a metal oxynitride, or a mixture of the two. The second component is coated on, or dispersed through the bulk of, the first component. The metal phosphate may be a lithiated metal phosphate and may be based upon one or more transition metals. Also disclosed is a method for preparing the material as well as electrodes fabricated from the material and lithium ion cells which include such electrodes.

IT 10124-54-6, Manganese phosphate 10402-24-1, Iron

10124-54-6, Manganese phosphate 10402-24-1, Iron phosphate 14542-94-0, Vanadium phosphate

RL: DEV (Device component use); USES (Uses)

(composite material and electrodes made therefrom for lithium battery cathode)

RN 10124-54-6 HCAPLUS

CN Phosphoric acid, manganese salt (8CI, 9CI) (CA INDEX NAME)

 $\bullet$ x Mn(x)

RN 10402-24-1 HCAPLUS CN Phosphoric acid, iron salt (8CI, 9CI) (CA INDEX NAME)

 $\bullet$ x Fe(x)

RN 14542-94-0 HCAPLUS CN Phosphoric acid, vanadium salt (8CI, 9CI) (CA INDEX NAME)

 $\bullet_{\mathbf{x}} V(\mathbf{x})$ 

IC ICM H01M

CC 52-2 (Electrochemical, Radiational, and Thermal Energy Technology) Section cross-reference(s): 72

ST lithium battery cathode composite material

IT Ball milling

Battery cathodes

(composite material and electrodes made therefrom for lithium battery cathode)

IT Nitrides

Olivine-group minerals

Transition metal nitrides

RL: DEV (Device component use); USES (Uses)

(composite material and electrodes made therefrom for lithium battery cathode)

IT Secondary batteries

(lithium; composite material and electrodes made

therefrom for lithium battery cathode)

IT Oxynitrides

Phosphates, uses

RL: DEV (Device component use); USES (Uses)
(metal; composite material and electrodes
made therefrom for lithium battery cathode)

IT Machining

(milling; composite material and electrodes
made therefrom for lithium battery cathode)

IT 7664-41-7, Ammonia, processes

RL: CPS (Chemical process); PEP (Physical, engineering or chemical process); PROC (Process)

(composite material and electrodes made therefrom for lithium battery cathode)

TT 7664-38-2D, Phosphoric acid, transition metal compds.
10124-54-6, Manganese phosphate 10402-24-1, Iron
phosphate 14542-94-0, Vanadium phosphate 77641-62-4,
Nasicon

RL: DEV (Device component use); USES (Uses)
 (composite material and electrodes made therefrom for
 lithium battery cathode)

IT 7429-90-5, Aluminum, uses 7439-95-4, Magnesium, uses 7440-03-1,
Niobium, uses 7440-32-6, Titanium, uses 7440-67-7, Zirconium,
uses

RL: MOA (Modifier or additive use); USES (Uses) (dopant; composite material and electrodes made therefrom for lithium battery cathode)

L56 ANSWER 7 OF 18 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER:

2004:589102 HCAPLUS

DOCUMENT NUMBER:

141:126371

TITLE:

INVENTOR (S):

Ionically conductive composites for

protection of active metal anodes in batteries

Visco, Steven J.; Nimon, Yevgeniy S.; Katz,

Bruce D.

PATENT ASSIGNEE(S):

Polyplus Battery Company, USA

SOURCE:

U.S. Pat. Appl. Publ., 23 pp., Cont.-in-part of

U.S. Ser. No. 686,189.

CODEN: USXXCO

DOCUMENT TYPE:

Patent

LANGUAGE:

English

FAMILY ACC. NUM. COUNT:

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
US 2004142244	A1	20040722	US 2003-731771	
				200312 05
US 2004126653	A1	20040701	US 2003-686189	
				200310
US 2004191617	A1	20040930	US 2004-772228	14
05 2004191617	ΑI	20040930	US 2004-772228	200402
				03
US 2004197641	A1	20041007	US 2004-772157	
				200402
WO 2005038062		20050420	WO 2004 MG22272	03 .
WO 2005038962	A2	20050428	WO 2004-US33372	200410 08

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WO 2005038962
                                20051229
                          Α3
         W: AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA,
             CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI,
             GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP,
             KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW,
             MX, MZ, NA, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD,
             SE, SG, SK, SL, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ,
             VC, VN, YU, ZA, ZM, ZW
         RW: BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW,
             AM, AZ, BY, KG, KZ, MD, RU, TJ, TM, AT, BE, BG, CH, CY, CZ,
             DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IT, LU, MC, NL, PL,
             PT, RO, SE, SI, SK, TR, BF, BJ, CF, CG, CI, CM, GA, GN, GQ,
             GW, ML, MR, NE, SN, TD, TG
PRIORITY APPLN. INFO.:
                                             US 2002-418899P
                                                                     200210
                                                                     15
                                             US 2003-686189
                                                                  A2
                                                                     200310
                                                                     14
                                             US 2003-511710P
                                                                     200310
                                                                     14
                                             US 2003-518948P
                                                                     200311
                                                                     10
                                             US 2003-526662P
                                                                     200312
                                                                     02
                                             US 2003-527098P
                                                                     200312
                                                                     03
                                             US 2003-731771
                                                                 A2
                                                                     200312
                                                                     05
                                             US 2004-536688P
                                                                 Ρ
                                                                     200401
                                                                     14
                                             US 2004-536689P
                                                                     200401
                                                                     14
                                             US 2004-772228
                                                                 Α
                                                                     200402
                                                                     03
```

AB Disclosed are ionically conductive composites for protection of active metal anodes and methods for their fabrication. The composites may be incorporated in active metal anode structures and battery cells. In accordance with the invention, the properties of different ionic conductors are combined in a composite material that has the desired properties of high overall ionic conductivity and chemical stability towards the anode, the

cathode and ambient conditions encountered in battery manufacturing The composite is capable of protecting an active metal anode from deleterious reaction with other battery components or ambient conditions while providing a high level of ionic conductivity to facilitate manufacture and/or enhance performance of a battery cell in which the composite is incorporated.

IT 10377-52-3

RL: TEM (Technical or engineered material use); USES (Uses) (ionically conductive composites for protection of active metal anodes in batteries)

RN 10377-52-3 HCAPLUS

CN Phosphoric acid, trilithium salt (8CI, 9CI) (CA INDEX NAME)

#### ●3 Li

IC : ICM H01M002-16 INCL 429246000; 429320000; 429322000 52-2 (Electrochemical, Radiational, and Thermal Energy Technology) Section cross-reference(s): 57 ST battery anode active metal protection ionically conductive composite Halides IT Nitrides RL: TEM (Technical or engineered material use); USES (Uses) (active metal; ionically conductive composites for protection of active metal anodes in batteries) IT Metals, uses RL: DEV (Device component use); USES (Uses) (active; ionically conductive composites for protection of active metal anodes in batteries) TT Battery anodes Ceramics Composites Glass ceramics Ionic conductivity Ionic conductors (ionically conductive composites for protection of active metal anodes in batteries) IT Secondary batteries (lithium; ionically conductive composites for protection of active metal anodes in batteries) Phosphate glasses TT RL: TEM (Technical or engineered material use); USES (Uses) (oxynitride, active metal; ionically conductive composites for protection of active metal anodes in batteries) Glass, uses RL: TEM (Technical or engineered material use); USES (Uses) (oxynitride, phosphorus oxynitride, active

metal; ionically conductive composites for

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protection of active metal anodes in batteries)
     Group VA element compounds
IT
     RL: TEM (Technical or engineered material use); USES (Uses)
        (phosphides, active metal; ionically conductive
        composites for protection of active metal anodes in
        batteries)
IT
     Sputtering
        (radio-frequency; ionically conductive composites for
        protection of active metal anodes in batteries)
     Lithium alloy, base
IT
     RL: DEV (Device component use); USES (Uses)
        (ionically conductive composites for protection of
        active metal anodes in batteries)
IT
     1310-53-8, Germania, uses 1314-23-4, Zirconia, uses 1314-56-3,
     Phosphorus oxide (P2O5), uses 1344-28-1, Alumina, uses
     7631-86-9, Silica, uses 12024-21-4, Gallium oxide (Ga2O3)
     12057-24-8, Lithium oxide (Li2O), uses 13463-67-7, Titania, uses
     RL: TEM (Technical or engineered material use); USES (Uses)
        (glass ceramic; ionically conductive composites for
        protection of active metal anodes in batteries)
IT
     7439-93-2, Lithium, uses
     RL: DEV (Device component use); USES (Uses)
        (ionically conductive composites for protection of
        active metal anodes in batteries)
IT
     1308-80-1, Copper nitride cu3n 7440-50-8, COpper, uses
     7447-41-8; Lithium chloride (LiCl), uses 7550-35-8, Lithium
     bromide 7789-24-4, Lithium fluoride, uses 10377-51-2, Lithium
     iodide 10377-52-3 12024-22-5, Gallium sulfide ga2s3
     12025-34-2, Germanium sulfide ges2 12057-29-3, Lithium phosphide
          12136-58-2, Lithium sulfide (Li2S) 13759-10-9, Silicon
     sulfide sis2 26134-62-3, Lithium nitride (Li3N) 70780-99-3,
             77641-62-4, Nasicon 184905-46-2, Lithium nitrogen
     Lisicon
     phosphorus oxide
     RL: TEM (Technical or engineered material use); USES (Uses)
        (ionically conductive composites for protection of
        active metal anodes in batteries)
ΙT
     11138-49-1, Sodium \beta-alumina 37220-89-6, Lithium
     B-alumina
     RL: TEM (Technical or engineered material use); USES (Uses)
        (of β-alumina type; ionically conductive composites
        for protection of active metal anodes in batteries)
L56 ANSWER 8 OF 18 HCAPLUS COPYRIGHT 2007 ACS on STN
ACCESSION NUMBER:
                        2004:355267 HCAPLUS
DOCUMENT NUMBER:
                        140:360340
TITLE:
                        Ionically conductive composites for
                        protection of active metal anodes of batteries
INVENTOR(S):
                       · Visco, Steven, Jr.; Nimon, Yevgeniy S.; Katz,
                        Bruce D.
PATENT ASSIGNEE(S):
                        Polyplus Battery Company, USA
                        PCT Int. Appl., 47 pp.
SOURCE:
                        CODEN: PIXXD2
DOCUMENT TYPE:
                        Patent
LANGUAGE:
                        English
FAMILY ACC. NUM. COUNT: 5
PATENT INFORMATION:
     PATENT NO.
                                         APPLICATION NO.
                       KIND
                               DATE
                                                                  DATE
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WO 2004036669
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                                                   WO 2003-US33457
                              A2
                                                                                200310
                                                                                14
                                      20050324
     WO 2004036669
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               CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB,
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               KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX,
               MZ, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN,
               YU, ZA, ZM, ZW
          RW: GH, GM, KE, LS, MW, MZ, SD, SL, SZ, TZ, UG, ZM, ZW, AM, AZ,
               BY, KG, KZ, MD, RU, TJ, TM, AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IT, LU, MC, NL, PT, RO, SE, SI, SK, TR, BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR,
               NE, SN, TD, TG
      CA 2502438
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                                      20040429
                                                    CA 2003-2502438
                                                                                200310
     AU 2003301383
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                                                                                14
     US 2004131944
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                                      20040708
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                                                                                14
     EP 1552572 ·
                              A2
                                      20050713
                                                    EP 2003-809186
                                                                                200310
               AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC,
               PT, IE, SI, LT, LV, FI, RO, MK, CY, AL, TR, BG, CZ, EE, HU,
               SK
     BR 2003015274
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     CN 1726608
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     JP 2006503416
                              Т
                                      20060126
                                                    JP 2004-545584
                                                                                200310
                                                                                14
PRIORITY APPLN. INFO.:
                                                    US 2002-418899P
                                                                                200210
                                                                                15
                                                    WO 2003-US33457
                                                                                200310
                                                                                14
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AB Disclosed are ionically conductive composites for protection of active metal anodes and methods for their fabrication. The composites may be incorporated in active metal anode structures and battery cells. In accordance with the invention, the properties of different ionic conductors are combined in a composite material that has the desired properties of high overall ionic conductivity and chemical stability towards the anode, the cathode and ambient conditions encountered in battery manufacturing. The composite is capable of protecting an active metal anode from deleterious reaction with other battery components or ambient conditions while providing a high level of ionic conductivity to facilitate manufacture and/or enhance performance of a battery cell in which the

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composite is incorporated.
IT
     10377-52-3, Trilithium phosphate
     RL: DEV (Device component use); USES (Uses)
        (ionically conductive composites for protection of
        active metal anodes of batteries)
RN
     10377-52-3 HCAPLUS
CN
     Phosphoric acid, trilithium salt (8CI, 9CI) (CA INDEX NAME)
   0
   - p— он
HO-
   OH
 ●3 Li
IC
     ICM H01M004-00
     52-2 (Electrochemical, Radiational, and Thermal Energy Technology)
CC
ST
     battery active metal anode protection ionically conductive
     composite
IT
     Glass, uses
     RL: DEV (Device component use); USES (Uses)
        (P-based; ionically conductive composites for
        protection of active metal anodes of batteries)
IT
     Halides
     RL: DEV (Device component use); USES (Uses)
        (active metal halides; ionically conductive composites
        for protection of active metal anodes of batteries)
IT
     Nitrides
     RL: DEV (Device component use); USES (Uses)
        (active metal nitrides; ionically conductive
        composites for protection of active metal anodes of
        batteries)
IT
    Glass, uses
     RL: DEV (Device component use); USES (Uses)
        (active metal phosphorus oxynitride;
        ionically conductive composites for protection of
        active metal anodes of batteries)
IT
     Selenides
     RL: DEV (Device component use); USES (Uses)
        (glass; ionically conductive composites for protection
        of active metal anodes of batteries)
IT
     Battery anodes
       Composites
     Glass ceramics
     Ionic conductivity
        (ionically conductive composites for protection of
        active metal anodes of batteries)
IT
     Alkali metals, uses
     Alkaline earth metals
     Sulfide glasses
     Transition metals, uses
     RL: DEV (Device component use); USES (Uses)
        (ionically conductive composites for protection of
        active metal anodes of batteries)
```

Group VA element compounds

IT

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RL: DEV (Device component use); USES (Uses)
        (phosphides, active metal phosphides; ionically conductive
        composites for protection of active metal anodes of
        batteries)
IT
     Glass, uses
     RL: DEV (Device component use); USES (Uses)
        (selenide; ionically conductive composites for
        protection of active metal anodes of batteries)
IT
    Lithium alloy, base
    RL: DEV (Device component use); USES (Uses)
        (ionically conductive composites for protection of
        active metal anodes of batteries)
IT
     7440-55-3, Gallium, uses 7440-56-4, Germanium, uses
    RL: DEV (Device component use); USES (Uses)
        (glass; ionically conductive composites for protection
        of active metal anodes of batteries)
IT
     1308-80-1, Copper nitride cu3n 1310-53-8, Germanium oxide (GeO2),
          1313-49-1, Zinc nitride zn3n2 1314-23-4, Zirconia, uses
     1314-56-3, Phosphorus oxide (P2O5), uses
                                               7439-93-2, Lithium, uses
     7447-41-8, Lithium chlori'de (LiCl), uses
                                                7550-35-8, Lithium
                     7553-56-2, Iodine, uses
                                                7631-86-9, Silica, uses
    bromide (LiBr)
     7723-14-0, Phosphorus, uses 7726-95-6, Bromine, uses 7782-41-4,
                     7782-50-5, Chlorine, uses 7789-24-4, Lithium
    Fluorine, uses
    fluoride, uses
                     10377-51-2, Lithium iodide (LiI) 10377-52-3
      Trilithium phosphate 12024-22-5, Gallium sulfide ga2s3
     12025-34-2, Germanium sulfide ges2 12033-89-5, Silicon nitride,
           12057-29-3, Lithium phosphide li3p
                                               12136-58-2, Dilithium
             13463-67-7, Titania, uses 13759-10-9, Silicon sulfide
    sulfide
           24304-00-5, Aluminum nitride Aln 25014-15-7,
    Poly(2-vinylpyridine) 26134-62-3, Lithium nitride (Li3N)
    37245-77-5, Iron nitride 55326-68-6, Cobalt nitride
                                                           55574-97-5,
                 70780-99-3, Lisicon 77641-62-4, Nasicon
    Tin nitride
    203402-92-0, Lithium nitride phosphate
    RL: DEV (Device component use); USES (Uses)
        (ionically conductive composites for protection of
        active metal anodes of batteries)
IT
    11138-49-1, Sodium \beta-alumina 37220-89-6, Lithium
    B-alumina
    RL: DEV (Device component use); USES (Uses)
        (of \beta-alumina type; ionically conductive composites
        for protection of active metal anodes of batteries)
L56 ANSWER 9 OF 18 HCAPLUS COPYRIGHT 2007 ACS on STN
ACCESSION NUMBER:
                        2004:278268 HCAPLUS
DOCUMENT NUMBER:
                        141:162713
TITLE:
                        Synthesis and characterization of TiOxNy
                        assembled in oxynitrided mesoporous
                        silica MCM-41
                        Zheng, Shan; Li, Zhengping; Gao, Lian
AUTHOR (S):
CORPORATE SOURCE:
                        Shanghai Institute of Ceramics, State Key Lab of
                        High Performance Ceramics and Superfine
                        Microstructure, Chinese Academy of Sciences,
                        Shanghai, 200050, Peop. Rep. China
SOURCE:
                        Materials Chemistry and Physics (2004), 85(1),
                        195-200
                        CODEN: MCHPDR; ISSN: 0254-0584
PUBLISHER:
                        Elsevier Science B.V.
DOCUMENT TYPE:
                        Journal
LANGUAGE:
                        English
```

Ti oxynitride (TiOxNy) with varying nitrogen contents assembled in

the pores of mesoporous material was achieved by nitriding TiO2-modified MCM-41 under flowing NH3 atmosphere. XRD, XPS, N2 adsorption-desorption isotherms and UV-visible spectra are employed to characterize the structure of the composite materials. Ti oxynitride is formed and crystallized at 700° when the nitridation time is 3 h. The MCM-41 host is also nitrided inevitably, while the mesostructure is still preserved. The effects of nitridation temperature on the formation of Ti oxynitride and structure of MCM-41 are systematically discussed.

CC 66-3 (Surface Chemistry and Colloids) Section cross-reference(s): 49, 57

IT Porous materials

(mesoporous, MCM-41; synthesis and characterization of TiOxNy assembled in oxynitrided mesoporous silica MCM-41)

IT 7631-86-9, Silica, processes

RL: CPS (Chemical process); NUU (Other use, unclassified); PEP (Physical, engineering or chemical process); PROC (Process); USES (Uses)

(mesoporous; synthesis and characterization of TiOxNy assembled in oxynitrided mesoporous silica MCM-41)

IT 37271-26-4P, Titanium oxynitride

RL: PRP (Properties); SPN (Synthetic preparation); PREP (Preparation)

(synthesis and characterization of TiOxNy assembled in oxynitrided mesoporous silica MCM-41)

IT 7664-41-7, Ammonia, reactions 13463-67-7, Titanium oxide (TiO2),
 reactions

RL: RCT (Reactant); RACT (Reactant or reagent)

21

(synthesis and characterization of TiOxNy assembled in oxynitrided mesoporous silica MCM-41)

REFERENCE COUNT:

THERE ARE 21 CITED REFERENCES AVAILABLE FOR THIS RECORD. ALL CITATIONS AVAILABLE IN THE RE FORMAT

L56 ANSWER 10 OF 18 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER:

2004:3712 HCAPLUS

DOCUMENT NUMBER:

140:82301

TITLE:

Prosthetic devices having diffusion-hardened

surfaces and bioceramic coatings

INVENTOR(S):

Hunter, Gordon; Gupta, Harsh; Heuer, Daniel; Long, Marc; Davidson, James; Mishra, Ajit

HOIL

PATENT ASSIGNEE(S): SOURCE:

U.S. Pat. Appl. Publ., 14 pp.

CODEN: USXXCO

DOCUMENT TYPE:

Patent

LANGUAGE:

English

FAMILY ACC. NUM. COUNT:

PATENT INFORMATION:

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
	US 2004002766	A1	20040101	US 2002-185386	
					200206
					27
PRI	ORITY APPLN. INFO.:			US 2002-185386	
					200206

AB A prosthetic device having at least part of its surface comprising a

diffusion-hardened, in-situ formed **oxidation** or nitridation layer (from zirconium, hafnium, niobium, or tantalum) and with at least another part of its surface comprising a coating of bioceramic, preferably hydroxyapatite. The bone in-growth and on-growth promoting bioceramic further works synergistically with the diffusion-hardened surface in realizing a longer service life prosthetic. Thus, the prosthesis is formed essentially from titanium 74, niobium 13, and zirconium 13% by weight 7757-93-9

RL: THU (Therapeutic use); BIOL (Biological study); USES (Uses) (prosthetic devices having diffusion-hardened surfaces and bioceramic coatings)

RN 7757-93-9 HCAPLUS

CN Phosphoric acid, calcium salt (1:1) (9CI) (CA INDEX NAME)

IT

#### Ca

IC ICM A61F002-30 INCL 623020210; 623022170; 623023530; 623023560 CC 63-7 (Pharmaceuticals) IT Prosthetic materials and Prosthetics (composites, implants; prosthetic devices having diffusion-hardened surfaces and bioceramic coatings) IT 471-34-1, Calcium carbonate, biological studies 3164-34-9, Calcium 7440-03-1D, Niobium, nitrided or tartrate 7440-25-7D, Tantalum, nitrided or oxidized 7440-58-6D, Hafnium, nitrided or oxidized 7440-67-7D, Zirconium, nitrided or oxidized oxidized 7757-93-9 7778-18-9, Calcium sulfate RL: THU (Therapeutic use); BIOL (Biological study); USES (Uses)

L56 ANSWER 11 OF 18 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER:

bioceramic coatings)

2003:261756 HCAPLUS

(prosthetic devices having diffusion-hardened surfaces and

DOCUMENT NUMBER:

138:275127

TITLE:

SOURCE:

Hybrid ceramic composite having

insulating and structural ceramic layers

INVENTOR (S):

Morrison, Jay A.; Burke, Michael A.; Merrill,

Gary B.; Lane, Jay E.

PATENT ASSIGNEE(S):

Siemens Westinghouse Power Corporation, USA

PCT Int. Appl., 28 pp.

CODEN: PIXXD2

DOCUMENT TYPE:

Patent

LANGUAGE:

English

FAMILY ACC. NUM. COUNT:

PATENT INFORMATION:

PATENT NO. KIND DATE APPLICATION NO. DATE

```
WO 2003026886
                          A2
                                 20030403
                                             WO 2002-US29343
                                                                      200209
                                                                      17
     WO 2003026886
                           A3
                                 20031106
         W: CA, JP
         RW: AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, IE,
             IT, LU, MC, NL, PT, SE, SK, TR
     US 2003207155
                                             US 2001-963278
                          A1
                                 20031106
                                                                      200109
                                                                      26
     US 6733907:
                                 20040511
                          B2
     CA 2461699
                          A1
                                 20030403
                                             CA 2002-2461699
                                                                      200209
                                                                      17
     EP 1432571
                          A2
                                 20040630
                                             EP 2002-799585
                                                                      200209
                                                                      17
             AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC,
             PT; IE, FI, CY, TR, BG, CZ, EE, SK
     JP 2005503940
                          Т
                                 20050210
                                            JP 2003-530502
                                                                      200209
                                                                      17
PRIORITY APPLN. INFO.:
                                           . US 2001-963278
                                                                      200109
                                                                      26
                                             US 1998-49328
                                                                  A3
                                                                      199803
                                                                     27
                                             US 1999-428197
                                                                  A3
                                                                      199910
                                                                     27
                                             US 2000-507794
                                                                  A2
                                                                     200002
                                                                     22
                                             WO 2002-US29343
                                                                  W
                                                                     200209
                                                                     17
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- AB A hybrid ceramic structure, for use in high temperature environments, e.g., gas turbines, is made from an insulating layer of porous ceramic that is thermally stable at ≤1700° bonded to a high mech. strength structural layer of denser ceramic that is thermally stable at ≤1200°, where optional high temperature resistant adhesive can bond the layers together, where optional cooling ducts can be present in the structural layer and where hot gas can contact the insulating layer and cold gas can contact the structural layer.
- T784-30-7P, Aluminum phosphate 13778-59-1P,
  Lanthanum phosphate 13990-54-0P, Yttrium phosphate
  RL: DEV (Device component use); PRP (Properties); SPN (Synthetic preparation); PREP (Preparation); USES (Uses)

(ceramic insulating layer; hybrid ceramic composites for gas turbines having insulating and structural ceramic layers) 7784-30-7 HCAPLUS

CN Phosphoric acid, aluminum salt (1:1) (9CI) (CA INDEX NAME)

RN

• Al

RN 13778-59-1 HCAPLUS
CN Phosphoric acid, lanthanum(3+) salt (1:1) (8CI, 9CI) (CA INDEX NAME)

La (III)

RN 13990-54-0 HCAPLUS
CN Phosphoric acid, yttrium(3+) salt (1:1) (8CI, 9CI) (CA INDEX NAME)

### ● Y(III)

IC ICM B32B018-00 ICS C04B037-00

CC 57-9 (Ceramics)

Section cross-reference(s): 47

ST hybrid composite layered porous insulating dens ceramic adhesive property; gas turbine layered hybrid ceramic composite adhesive heat resistant

IT Grains (particles)

(additives; hybrid ceramic composites for gas turbines having insulating and structural ceramic layers)

IT Synthetic fibers

RL: CPS (Chemical process); MOA (Modifier or additive use); PEP (Physical, engineering or chemical process); PROC (Process); USES (Uses)

(aluminum oxide; hybrid ceramic composites for gas turbines having insulating and structural ceramic layers)

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IT
     Synthetic fibers
     RL: CPS (Chemical process); MOA (Modifier or additive use); PEP
     (Physical, engineering or chemical process); PROC (Process); USES
     (Uses)
        (aluminum yttrium zirconium oxide; hybrid ceramic
        composites for gas turbines having insulating and
        structural ceramic layers)
IT
     Molding of ceramics
        (casting, pressure; hybrid ceramic composites for gas
        turbines having insulating and structural ceramic layers)
IT
     Hafnia
        (ceramic insulating layer; hybrid ceramic composites
        for gas turbines having insulating and structural ceramic layers)
IT
     Vapor deposition process
        (chemical, infiltration; hybrid ceramic composites for gas
        turbines having insulating and structural ceramic layers)
IT
     Vapor deposition process
        (chemical; hybrid ceramic composites for gas turbines
        having insulating and structural ceramic layers)
IT
     Turbines
        (combustor; hybrid ceramic composites for gas turbines
        having insulating and structural ceramic layers)
IT
     Coating materials
        (erosion-resistant; hybrid ceramic composites for gas
        turbines having insulating and structural ceramic layers)
IT
     Ceramics
        (fibers; hybrid ceramic composites for gas turbines
        having insulating and structural ceramic layers)
IT
     Spheres
        (hollow, ceramics; hybrid ceramic composites for gas
        turbines having insulating and structural ceramic layers)
TT
     Sintering
        (hot isostatic pressing; hybrid ceramic composites for
        gas turbines having insulating and structural ceramic layers)
TT
     Sintering
        (hot pressing; hybrid ceramic composites for gas
        turbines having insulating and structural ceramic layers)
IT
     Adhesives
     Annealing
     Cooling
     Densification
     Firing (heat treating)
     Glazing (ceramic)
     Hybrid organic-inorganic materials
       Nitriding
     Sintering
     Sol-gel processing
     Surface treatment
     Thermal stability
     Turbines
     Vapor deposition process
        (hybrid ceramic composites for gas turbines having
        insulating and structural ceramic layers)
IT
     Composites
        (hybrid ceramic; hybrid ceramic composites for gas
        turbines having insulating and structural ceramic layers)
IT
     Polymers, processes
     RL: CPS (Chemical process); PEP (Physical, engineering or chemical
     process); PROC (Process)
        (impregnation; hybrid ceramic composites for
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gas turbines having insulating and structural ceramic layers)
IT
     Materials
         (layered; hybrid ceramic composites for gas turbines
        having insulating and structural ceramic layers)
TΤ
     Filaments
         (monofilaments, additives; hybrid ceramic composites
        for gas turbines having insulating and structural ceramic layers)
IT
     Synthetic fibers
     RL: CPS (Chemical process); MOA (Modifier or additive use); PEP
      (Physical, engineering or chemical process); PROC (Process); USES
         (mullite; hybrid ceramic composites for gas turbines
        having insulating and structural ceramic layers)
IT
     Oxidation
         (of metal; hybrid ceramic composites for gas turbines
        having insulating and structural ceramic layers)
IT
     Thermal decomposition
         (of polymers; hybrid ceramic composites for gas
        turbines having insulating and structural ceramic layers)
'IT
     Heat-resistant materials
         (porous ceramic insulating layer and adhesive; hybrid ceramic
        composites for gas turbines having insulating and
        structural ceramic layers)
TT
     Ceramics
        (porous, insulating layer; hybrid ceramic composites
        for gas turbines having insulating and structural ceramic layers)
IT
     Sintering
        (pressureless; hybrid ceramic composites for gas
        turbines having insulating and structural ceramic layers)
TT
     Coating materials
        (protective debonding interface; hybrid ceramic
        composites for gas turbines having insulating and
        structural ceramic layers)
IT
     Impregnation
        (slurry; hybrid ceramic composites for gas turbines
        having insulating and structural ceramic layers)
IT
        (spheres, hollow; hybrid ceramic composites for gas
        turbines having insulating and structural ceramic layers)
IT
     RL: CPS (Chemical process); MOA (Modifier or additive use); PEP
     (Physical, engineering or chemical process); PROC (Process); USES
        (tow, polycryst. multi-filament, additives; hybrid ceramic
        composites for gas turbines having insulating and
        structural ceramic layers)
IT
     Diffusion
        (vacuum; hybrid ceramic composites for gas turbines
        having insulating and structural ceramic layers)
IT
     1302-93-8P, Mullite
                           1344-28-1P, Alumina, preparation
     12005-21-9P, YAG
     RL: CPS (Chemical process); DEV (Device component use); PEP
     (Physical, engineering or chemical process); PRP (Properties); SPN
     (Synthetic preparation); PREP (Preparation); PROC (Process); USES
     (Uses)
        (ceramic insulating layer and fibers; hybrid ceramic
        composites for gas turbines having insulating and
        structural ceramic layers)
IT
     1304-28-5P, Barium oxide, preparation 1304-56-9P, Beryllia,
     preparation
                  1305-78-8P, Calcia, preparation
                                                     1306-38-3P, Ceria,
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1308-38-9P, Chromia, preparation
preparation
                                                1309-48-4P,
Magnesia, preparation 1313-99-1P, Nickel oxide, preparation
1314-23-4P, Zirconia, preparation 1314-36-9P, Yttria, preparation
1314-37-0P, Ytterbium oxide 1327-43-1P, Aluminum magnesium silicon
oxide .7631-86-9P, Silica, preparation 7784-30-7P,
Aluminum phosphate 11099-11-9P, Vanadium oxide
                                                  11104-48-6P,
                        11137-98-7P, Aluminum magnesium oxide
Calcium aluminum oxide
12009-21-1P, Barium zirconium oxide 12013-47-7P, Calcium zirconium
       12036-39-4P, Strontium zirconium oxide 12060-08-1P,
Scandium oxide 12061-16-4P, Erbium oxide 12183-66-3P, Germanium
hafnium oxide (GeHfO4)
                        12789-67-2P, Calcium tungsten oxide
13463-67-7P, Titania, preparation 13778-59-1P, Lanthanum
phosphate 13990-54-0P, Yttrium phosphate 14940-68-2P,
Zircon
        37264-65-6P, Aluminum cerium oxide 39300-74-8P, Germanium
              39318-32-6P, Magnesium zirconium oxide
yttrium oxide
39354-08-0P, Aluminum nickel oxide 39407-05-1P, Praseodymium
                 51331-24-9P, Lanthanum zirconium oxide
zirconium oxide
51680-38-7P, Hafnium lanthanum oxide 63439-80-5P, Calcium silicon
       111569-09-6P, Scandium zirconium oxide
                                               123243-35-6P,
Cerium germanium oxide 144716-88-1P, Calcium hafnium oxide
151640-29-8P, Barium hafnium oxide 155553-83-6P, Aluminum calcium
silicon oxide 155553-85-8P, Magnesium silicon oxide
157822-16-7P, Hafnium magnesium oxide 165449-00-3P, Hafnium
strontium oxide 170214-74-1P, Hafnium praseodymium oxide
223720-69-2P, Germanium zirconium oxide
RL: DEV (Device component use); PRP (Properties); SPN (Synthetic
preparation); PREP (Preparation); USES (Uses)
   (ceramic insulating layer; hybrid ceramic composites
  for gas turbines having insulating and structural ceramic layers)
7440-44-0P, Carbon, preparation 137753-05-0P, Boron carbide
nitride silicide
RL: PRP (Properties); SPN (Synthetic preparation); TEM (Technical or
engineered material use); PREP (Preparation); USES (Uses)
   (fiber coating; hybrid ceramic composites for gas
   turbines having insulating and structural ceramic layers)
1317-82-4P, Sapphire 1335-30-4P, Aluminum silicate
RL: CPS (Chemical process); DEV (Device component use); PEP
(Physical, engineering or chemical process); PRP (Properties); SPN
(Synthetic preparation); PREP (Preparation); PROC (Process); USES
(Uses)
   (fibers; hybrid ceramic composites for gas turbines
   having insulating and structural ceramic layers)
10043-11-5P, Boron nitride, preparation
RL: CPS (Chemical process); DEV (Device component use); PEP
(Physical, engineering or chemical process); PRP (Properties); SPN
(Synthetic preparation); PREP (Preparation); PROC (Process); USES
(Uses)
   (hybrid ceramic composite layer and coating; hybrid
   ceramic composites for gas turbines having insulating
   and structural ceramic layers)
409-21-2P, Silicon carbide, preparation
RL: CPS (Chemical process); DEV (Device component use); PEP
(Physical, engineering or chemical process); PRP (Properties); SPN
(Synthetic preparation); PREP (Preparation); PROC (Process); USES
(Uses)
   (hybrid ceramic composite layer and filaments and
   coating; hybrid ceramic composites for gas turbines
  having insulating and structural ceramic layers)
12033-89-5P, Silicon nitride, preparation 64477-28-7P, Silicon
carbide nitride
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TΤ

IT

IT

IT

GCantelmo 10/766,385 RL: CPS (Chemical process); DEV (Device component use); PEP (Physical, engineering or chemical process); PRP (Properties); SPN (Synthetic preparation); PREP (Preparation); PROC (Process); USES (Uses) (hybrid ceramic composite layer and filaments; hybrid ceramic composites for gas turbines having insulating and structural ceramic layers) 11104-85-1P, Molybdenum silicide 11130-49-7P, Chromium carbide 11130-73-7P, Tungsten carbide 12007-23-7P, Hafnium boride 12033-62-4P, Tantalum nitride 12045-63-5P, Titanium boride 12069-85-1P, Hafnium carbide 12045-64-6P, Zirconium boride 12069-94-2P, Niobium carbide 12070-06-3P, Tantalum carbide 12070-08-5P, Titanium carbide 12070-14-3P, Zirconium carbide 12626-91-4P, Molybdenum boride 12626-44-7P, Chromium silicide

12626-44-7P, Chromium silicide 12626-91-4P, Molybdenum boride 12627-57-5P, Molybdenum carbide 12648-34-9P, Niobium nitride 12653-55-3P, Chromium boride 12653-77-9P, Niobium boride

12653-85-9P, Tantalum boride 12738-91-9P, Titanium silicide 25583-20-4P, Titanium nitride 25817-87-2P, Hafnium nitride 37189-51-8P, Zirconium silicide 37245-81-1P, Molybdenum nitride 2653-88-2P, Vanadium boride 24304-00-5P, Aluminum nitride 25658-42-8P, Zirconium silicide 37189-51-8P, Niobium silicide

52953-72-7P, Tantalum silicide 60304-33-8P, Hafnium silicide RL: DEV (Device component use); PRP (Properties); SPN (Synthetic preparation); PREP (Preparation); USES (Uses) (hybrid ceramic composite layer; hybrid ceramic

composites for gas turbines having insulating and structural ceramic layers)

IT 7440-32-6, Titanium, uses 7440-42-8, Boron, uses 7440-67-7, Zirconium, uses

RL: MOA (Modifier or additive use); USES (Uses)
(hybrid ceramic composites for gas turbines having insulating and structural ceramic layers)

L56 ANSWER 12 OF 18 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER:

2002:830297 HCAPLUS

DOCUMENT NUMBER:

137:332079

TITLE:

IT

PTCR composite material for current

limiters

INVENTOR (S):

Ishida, Yoshihiko

PATENT ASSIGNEE(S):

NGK Insulators, Ltd., Japan

SOURCE:

U.S., 10 pp., Cont.-in-part of U.S. 6,300,862.

CODEN: USXXAM

DOCUMENT TYPE:

Patent

LANGUAGE:

English

FAMILY ACC. NUM. COUNT:

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE -
US 6472972	B1	20021029	US 2000-570749	200005
US 6300862	B1	20011009	US 2000-497845	15 200002
EP 1122211	A1	20010808	EP 2001-300778	03 200101
EP 1122211	B1	20031112		30

R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT, IE, SI, LT, LV, FI, RO 20010831 JP 2001-25949 JP 2001237104 Α 200102 01 CN 1307342 Α 20010808 CN 2001-103209 200102 05 PRIORITY APPLN. INFO.: US 2000-497845 A2 200002 03 US 2000-570749 200005 15

AB A reusable PTCR composite material with low room-temperature resistance, large resistance jump at the transition temperature, a transition temperature <200°, high heat resistance, and low power loss consists of a matrix of ceramic material having one of a cristobalite crystal structure and a tridymite crystal structure, each doped with an oxide of at least one of Be, B, Mg, Al, Ca, Sc, Ti, V, Cr, Mn, Fe, Co, Ni, Cu, Zn, Ga, Ge and W, and a conductive phase dispersed throughout the matrix. The conductive phase includes at least one of a metal, silicide, nitride, carbide and boride.

T7784-30-7, Aluminum phosphate (AlPO4)
RL: PEP (Physical, engineering or chemical process); PYP (Physical process); TEM (Technical or engineered material use); PROC (Process); USES (Uses)

(PTCR composite material for current limiters)

RN 7784-30-7 HCAPLUS

CN Phosphoric acid, aluminum salt (1:1) (9CI) (CA INDEX NAME)

#### Al

IC ICM H01B001-02 ICS H01B001-06; H01B001-04; H01C007-10; H01C007-13 INCL 338-22R 76-14 (Electric Phenomena) CC Section cross-reference(s): 57 ST PTCR ceramic composite current limiter sintering IT Ceramic composites PTCR materials (PTCR composite material for current limiters) IT Binders Dopants Electrodes Powders Sintering aids

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(for PTCR composite material for current limiters)
ΙT
     Epoxy resins, processes
     Polyimides, processes
     Polythiophenylenes
     RL: PEP (Physical, engineering or chemical process); PYP (Physical
     process); TEM (Technical or engineered material use); PROC
     (Process); USES (Uses)
        (for PTCR composite material for current limiters)
IT
     Transition metal silicides
     RL: TEM (Technical or engineered material use); USES (Uses)
        (for PTCR composite material for current limiters)
IT
     Ball milling
     Particle size
     Sintering
        (of PTCR composite material for current limiters)
     Polyimides, processes
IT
     RL: PEP (Physical, engineering or chemical process); PYP (Physical
     process); TEM (Technical or engineered material use); PROC
     (Process); USES (Uses)
        (polyamide-; for PTCR 'composite material for current
        limiters)
IT
     Polyamides, processes
     RL: PEP (Physical; engineering or chemical process); PYP (Physical
     process); TEM (Technical or engineered material use); PROC
     (Process); USES (Uses)
        (polyimide-; for PTCR composite material for current
        limiters)
IT
     Chromium alloy, base
     Cobalt alloy, base
     Iron alloy, base
     Molybdenum alloy, base
     Nickel alloy, base
     Niobium alloy, base
     Platinum alloy, base
     Rhodium alloy, base
     Titanium alloy, base
     Tungsten alloy, base
     Zirconium alloy, base
     RL: TEM (Technical or engineered material use); USES (Uses)
        (for PTCR composite material for current limiters)
IT
     7631-86-9, Silica, processes 7784-30-7, Aluminum phosphate
     (AlPO4)
     RL: PEP (Physical, engineering or chemical process); PYP (Physical
     process); TEM (Technical or engineered material use); PROC
     (Process); USES (Uses)
        (PTCR composite material for current limiters)
    1344-28-1, Alumina, uses 14464-46-1, Cristobalite Quartz, uses 15468-32-3, Tridymite
IT
                                                            14808-60-7,
     RL: TEM (Technical or engineered material use); USES (Uses)
        (PTCR composite material for current limiters)
     7732-18-5, Water, processes 7782-44-7, Oxygen, processes
IT
     RL: CPS (Chemical process); NUU (Other use, unclassified); PEP
     (Physical, engineering or chemical process); PROC (Process); USES
     (Uses)
        (for PTCR composite material for current limiters)
IT
     1303-86-2, Boron oxide (B2O3), uses 1304-56-9, Beryllium oxide
     (BeO), uses 1305-78-8, Calcium oxide (CaO), uses 1308-38-9,
     Chromium oxide (Cr2O3), uses 1309-48-4, Magnesium oxide (MgO),
            1310-53-8, Germanium oxide (GeO2), uses 1313-99-1, Nickel
                         1314-13-2, Zinc oxide (ZnO), uses
     oxide (NiO), uses
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1314-62-1, Vanadium oxide (V2O5), uses

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1332-37-2, Iron oxide, uses 1344-70-3, Copper oxide 11104-61-3,
     Cobalt oxide
                   11129-60-5, Manganese oxide
                                                   12024-21-4, Gallium
                     12060-08-1, Scandium oxide (Sc203)
     oxide (Ga2O3)
     RL: MOA (Modifier or additive use); USES (Uses)
        (for PTCR composite material for current limiters)
IT
     13463-67-7, Titanium oxide (TiO2), uses
     RL: MOA (Modifier or additive use); TEM (Technical or engineered
     material use); USES (Uses)
        (for PTCR composite material for current limiters)
IT
     7439-98-7, Molybdenum, processes 9004-73-3, Polymethylsiloxane
     12034-80-9, Niobium silicide (NbSi2) 12039-79-1, Tantalum silicide
              12136-78-6, Molybdenum silicide (MoSi2)
                                                          26062-94-2,
     Polybutyleneterephthalate
     RL: PEP (Physical, engineering or chemical process); PYP (Physical
     process); TEM (Technical or engineered material use); PROC
     (Process); USES (Uses)
        (for PTCR composite material for current limiters)
IT
     7439-89-6, Iron, uses 7440-02-0, Nickel, uses 7440-03-1,
     Niobium, uses 7440-06-4, Platinum, uses 7440-16-6, Rhodium, uses
     7440-32-6, Titanium, uses 7440-33-7, Tungsten, uses 7440-47-3, Chromium, uses 7440-48-4, Cobalt, uses 7440-67-7, Zirconium,
                                          11104-85-1, Molybdenum silicide
            11104-62-4, Cobalt silicide
                                    12626-76-5, Iron silicide
     12626-44-7, Chromium silicide
     12627-41-7, Tungsten silicide
                                     12738-91-9, Titanium silicide
     37189-51-8, Zirconium silicide 39336-13-5, Niobium silicide
     52037-56-6, Vanadium silicide
                                    52953-72-7, Tantalum silicide
     RL: TEM (Technical or engineered material use); USES (Uses)
        (for PTCR composite material for current limiters)
IT
     144-55-8, Sodium carbonate (NaHCO3), uses
     RL: MOA (Modifier or additive use); USES (Uses)
        (sintering aid; PTCR composite material for current
        limiters)
     298-14-6, Potassium carbonate (KHCO3)
IT
     RL: MOA (Modifier or additive use); USES (Uses)
        (sintering aid; for PTCR composite material for current
        limiters)
REFERENCE COUNT:
                                THERE ARE 2 CITED REFERENCES AVAILABLE FOR
                         2
                                THIS RECORD. ALL CITATIONS AVAILABLE IN
                                THE RE FORMAT
L56 ANSWER 13 OF 18 HCAPLUS COPYRIGHT 2007 ACS on STN
ACCESSION NUMBER:
                         2002:256646 HCAPLUS
DOCUMENT NUMBER:
                         136:265842
TITLE:
                         Composite electrode material, its
                         manufacture, and secondary battery using the
                         material
                         Yamada, Masayuki; Miyamoto, Miwa; Yokoyama, Eri;
INVENTOR (S):
                         Koyama, Toshihiro; Saibara, Shoji; Aoyama,
                         Shigeo
PATENT ASSIGNEE(S):
                         Hitachi Maxell Ltd., Japan
SOURCE:
                         PCT Int. Appl., 23 pp.
                         CODEN: PIXXD2
DOCUMENT TYPE:
                         Patent
LANGUAGE:
                         Japanese
FAMILY ACC. NUM. COUNT:
PATENT INFORMATION:
     PATENT NO.
                         KIND
                                DATE
                                            APPLICATION NO.
                                                                     DATE
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Tungsten oxide (WO3), uses

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WO 2002027825
                                   20020404
                                                WO 2001-JP8348
                            Α1
                                                                          200109
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              AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BY, BZ, CA, CH,
              CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, ES, FI, GB, GD,
              GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KR, KZ, LC,
              LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NO,
              NZ, PH, PL, PT, RO, RU, SD, SE, SG, SI, SK, SL, TJ, TM, TR,
              TT, TZ, UA, UG, US, UZ, VN, YU, ZA, ZW
         RW: GH, GM, KE, LS, MW, MZ, SD, SL, SZ, TZ, UG, ZW, AT, BE, CH,
              CY, DE, DK, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE, TR, BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN,
              TD, TG
     AU 2001090268
                            A5
                                   20020408
                                                AU 2001-90268
                                                                          200109
                                                                          26
     DE 10196256
                            TO.
                                   20030821
                                                DE 2001-10196256
                                                                          200109
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     US 2003142466
                            A1
                                   20030731
                                                US 2002-275035
                                                                          200210
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     US 6989218
                            B2
                                   20060124
PRIORITY APPLN. INFO.:
                                                JP 2000-296478
                                                                          200009
                                                                          28
                                                JP 2001-253239
                                                                          200108
                                                                          23
                                                WO 2001-JP8348
                                                                          200109
                                                                          26
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AB The composite electrode material has a 0.01-30 μm Li transition metal nitride cores coated with a Li intercalating or Li+ conducting material, other than Li transition metal nitride, on their surface and is prepared by vapor phase deposition method to form the coating. The transition metal in the nitride is selected from Co, Cu, Fe, and Ni; the Li intercalating material is a carbonaceous material or a metal or its oxide or nitride. A secondary Li battery uses the material for cathode and/or anode.

IT 1308-80-1, Copper nitride (Cu3N) 10377-52-3,

Lithium phosphate

RL: DEV (Device component use); PEP (Physical, engineering or chemical process); PROC (Process); USES (Uses)

(lithium intercalating and lithium conducting material coated lithium transition metal nitride for

secondary lithium battery electrodes)

RN 1308-80-1 HCAPLUS

CN Copper nitride (Cu3N) (6CI, 7CI, 8CI, 9CI) (CA INDEX NAME)

Cu | Cu-N-Cu

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RN
     10377-52-3 HCAPLUS
     Phosphoric acid, trilithium salt (8CI, 9CI) (CA INDEX NAME)
CN
   0
но- р- он
   OH
●3 Li
IC
     ICM H01M004-58
     ICS H01M004-02; H01M010-40; H01G009-00
CC
     52-2 (Electrochemical, Radiational, and Thermal Energy Technology)
ST
     secondary lithium battery electrode lithium transition metal
     nitride; electrode lithium transition metal
     nitride vapor phase coating
IT
     Vapor deposition process
        (chemical; CVD deposition of coating materials on lithium transition
        metal nitride for secondary lithium battery
        electrodes)
IT
     Battery anode's
        (lithium intercalating and lithium conducting material coated
        lithium transition metal nitride for
        secondary lithium battery electrodes)
     Carbonaceous materials (technological products)
IT
     RL: DEV (Device component use); PEP (Physical, engineering or
     chemical process); PROC (Process); USES (Uses)
        (lithium intercalating and lithium conducting material coated
        lithium transition metal nitride for
        secondary lithium battery electrodes)
IT
     Sputtering
        (sputtering deposition of coating materials on lithium transition
       metal nitride for secondary lithium battery
        electrodes)
IT
     Vapor deposition process
        (vapor phase deposition of coating materials on lithium
        transition metal nitride for secondary
        lithium battery electrodes)
IT
     174421-80-8P, Cobalt lithium nitride (Co0.4Li2.6N)
     RL: DEV (Device component use); IMF (Industrial manufacture); PEP
     (Physical, engineering or chemical process); PYP (Physical process);
     PREP (Preparation); PROC (Process); USES (Uses)
        (lithium intercalating and lithium conducting material coated
        lithium transition metal nitride for
        secondary lithium battery electrodes)
IT
     1308-80-1, Copper nitride (Cu3N)
                                       7429-90-5, Aluminum, uses
     10377-52-3, Lithium phosphate
                                   63985-45-5, Lithium
     orthosilicate 113443-18-8, Silicon oxide (SiO)
     RL: DEV (Device component use); PEP (Physical, engineering or
     chemical process); PROC (Process); USES (Uses)
        (lithium intercalating and lithium conducting material coated
        lithium transition metal nitride for
        secondary lithium battery electrodes)
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THERE ARE 11 CITED REFERENCES AVAILABLE

11

REFERENCE COUNT:

# FOR THIS RECORD. ALL CITATIONS AVAILABLE IN THE RE FORMAT

L56 ANSWER 14 OF 18 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER:

2001:581469 HCAPLUS

DOCUMENT NUMBER:

135:126119

TITLE:

Ceramic matrix composites with

positive temperature coefficient (PTC) of

resistance for current limiters

INVENTOR (S):

Ishida, Yoshihiko

PATENT ASSIGNEE(S):

Ngk Insulators, Ltd., Japan Eur. Pat. Appl., 16 pp.

CODEN: EPXXDW

DOCUMENT TYPE:

Patent

LANGUAGE:

SOURCE:

English

FAMILY ACC. NUM. COUNT:

PATENT INFORMATION:

	PAT	ENT	NO.			KIN	D -	DATE		AP:	PLICAT	ION NO			DATE
	EP	1122	- 211			A1		2001	0808	EP	2001-	300778			200101
	EP	1122	211			В1		2003	1112						30
		R:						, ES,		GB, G	R, IT,	LI, L	U, N	L, SE	, MC,
	US	6300	862	•	•	В1		2001	1009	US	2000-	497845			
					•										200002
	US	6472	972			В1		2002	1029	US	2000-	570749			20005
															200005 15
PRIO	RITY	APP	LN.	INFO.	:					US	2000-	497845		A	200002
															03
										IIS	2000-	570749		A	
										•••					200005
															15

- AB The PTC composites include a matrix of ceramic having one of a cristobalite crystal structure and a tridymite crystal structure (SiO2 and AlPO4), each doped with 0.1-20 mol.% of an oxide of ≥1 of Be, B, Mg, Al, Ca, Sc, Ti, V, Cr, Mn, Fe, Co, Ni, Cu, Zn, Ga, Ge, and W, and 10-45 volume% of a conductive phase dispersed throughout the matrix. The preferred oxide is a tungstate present in an amount of 1-5 mol. % in the matrix phase. conductive phase includes ≥1 of a metal, silicide, nitride, carbide, and boride of Ti, Zr, V, Nb, Ta, Cr, Mo, W, Co, or Fe. The materials can also contain a polymer to make it more flexible, e.g., polymethyl siloxane, epoxy resin, polyimide, polybutylene terephthalate, polyphenylene sulfide, and polyamideimide. The PTC material further comprises a composite electrode layer formed on at least one surface of said PTC material, comprising a matrix material and a conductive component. The thickness of said composite electrode is <50 % of the thickness of said PTC material.
- 7784-30-7, Aluminum phosphate (AlPO4) RL: TEM (Technical or engineered material use); USES (Uses)

Al

IC ICM C01B025-36 ICS C04B035-14; H01C007-02 CC 57-2 (Ceramics) ST ceramic conductive composite pos temp coeff; silica aluminum phosphate ceramic cristobalite tridymite IT Epoxy resins, uses Polyimides, uses Polythiophenylenes RL: MOA (Modifier or additive use); USES (Uses) (binder; ceramic matrix composites with pos. temperature coefficient (PTC) of resistance for current limiters) IT Ceramic composites (cristobalite and tridymite matrix; ceramic matrix composites with pos. temperature coefficient (PTC) of resistance for current limiters) Superconductor devices IT (current limiters, ceramic conductive composites; ceramic matrix composites with pos. temperature coefficient (PTC) of resistance for current limiters) Oxides (inorganic), uses IT RL: MOA (Modifier or additive use); USES (Uses) (dopants of ceramic matrix; ceramic matrix composites with pos. temperature coefficient (PTC) of resistance for current limiters) IT Silicides RL: TEM (Technical or engineered material use); USES (Uses) (of Ti, Zr, V, Cr, W, Co, or Fe, conductive phase; ceramic matrix composites with pos. temperature coefficient (PTC) of resistance for current limiters) Borides ΙT Carbides Nitrides RL: TEM (Technical or engineered material use); USES (Uses) (of Ti, Zr, V, Nb, Ta, Cr, Mo, W, Co, or Fe, conductive phase; ceramic matrix composites with pos. temperature coefficient (PTC) of resistance for current limiters) ΙT Polyimides, uses RL: MOA (Modifier or additive use); USES (Uses) (polyamide-, binder; ceramic matrix composites with pos. temperature coefficient (PTC) of resistance for current limiters) IT Polyamides, uses RL: MOA (Modifier or additive use); USES (Uses)

```
(polyimide-, binder; ceramic matrix composites with
        pos. temperature coefficient (PTC) of resistance for current limiters)
IT
     Electric resistance
        (pos. temperature coefficient of; ceramic matrix composites with
        pos. temperature coefficient (PTC) of resistance for current limiters)
     9004-73-3, Polymethyl siloxane
TT
                                       24968-12-5, Polybutylene
     terephthalate
     RL: MOA (Modifier or additive use); USES (Uses)
        (binder; ceramic matrix composites with pos. temperature
        coefficient (PTC) of resistance for current limiters)
     7439-98-7, Molybdenum, uses 12034-80-9, Niobium disilicide
IT
     12039-79-1, Tantalum disilicide 12136-78-6, Molybdenum disilicide
     RL: TEM (Technical or engineered material use); USES (Uses)
        (conductive phase; ceramic matrix composites with pos.
        temperature coefficient (PTC) of resistance for current limiters)
IT
     12737-86-9, tungstate
     RL: TEM (Technical or engineered material use); USES (Uses)
        (dopant of ceramic matrix; ceramic matrix
        composites with pos. temperature coefficient (PTC) of resistance for
        current limiters)
     1303-86-2, Boron oxide, uses
     1303-86-2, Boron oxide, uses 1344-28-1, Alumina, uses RL: MOA (Modifier or additive use); USES (Uses)
IT
        (dopants of ceramic matrix; ceramic matrix
        composites with pos. temperature coefficient (PTC) of resistance for
        current limiters)
     7631-86-9, Silica, uses 7784-30-7; Aluminum phosphate
IT
     (Alpo4)
     RL: TEM (Technical or engineered material use); USES (Uses)
        (matrix of ceramic composite, cristobalite and
        tridymite phases; ceramic matrix composites with pos.
        temperature coefficient (PTC) of resistance for current limiters)
     14464-46-1, Cristobalite 15468-32-3, Tridymite
IT
     RL: TEM (Technical or engineered material use); USES (Uses)
        (phases of SiO2 and AlPO4; ceramic matrix composites
        with pos. temperature coefficient (PTC) of resistance for current limiters)
IT
     144-55-8, Carbonic acid monosodium salt, uses
                                                      298-14-6
     RL: MOA (Modifier or additive use); USES (Uses)
        (sintering aid; ceramic matrix composites with pos.
        temperature coefficient (PTC) of resistance for current limiters)
REFERENCE COUNT:
                                THERE ARE 6 CITED REFERENCES AVAILABLE FOR
                                THIS RECORD. ALL CITATIONS AVAILABLE IN
                                THE RE FORMAT
L56 ANSWER 15 OF 18 HCAPLUS COPYRIGHT 2007 ACS on STN
ACCESSION NUMBER:
                         1999:337068 HCAPLUS
DOCUMENT NUMBER:
                         131:8107
TITLE:
                         Use of ion beam etching for producing
                         topographical microstructure
AUTHOR (S):
                         Koch, Marlen
CORPORATE SOURCE:
                         Inst. Metallkunde, TU Bergakademie Freiberg,
                         Freiberg, D-09599, Germany
SOURCE:
                         Praktische Metallographie (1999), 36(5), 233-249
                         CODEN: PMTLA5; ISSN: 0032-678X
PUBLISHER:
                         Carl Hanser Verlag
DOCUMENT TYPE:
                         Journal
LANGUAGE:
                         German/English
     The results of structure contrasting of composites (Cr
     coatings on brass, Cu electroplates on Cu or Fe) and complex compds.
     (Bi-Pb high-Tc superconductors) using both ion beam (IBE) and chemical
     etching (CE) techniques were compared. The obtained topog.
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microstructures were analyzed by SEM, optical light, scanning tunnel, and atomic force microscopy. The effort for preparing the samples is similar for IBE and other etching techniques. With IBE, the structure formation is not affected by the electrochem. p.d. between the components of a composite resulting in a better structure contrasting. Therefore, IBE was established as a helpful tool for producing topog. microstructures of complex compds., especially if conventional structure contrasting methods failed.

CC 56-6 (Nonferrous Metals and Alloys)

IT Sputtering

Sputtering

(etching, ion-beam; ion beam etching for formation of structure contrasting of composites)

IT Metallography

(ion beam etching for formation of structure contrasting of composites)

IT Etching Etching

(sputter, ion-beam; ion beam etching for formation of structure contrasting of composites)

IT 7440-47-3, Chromium, processes

RL: PEP (Physical, engineering or chemical process); PROC (Process) (PVD-layer; ion beam etching for formation of structure contrasting of composites)

IT 7440-50-8, Copper, processes

RL: PEP (Physical, engineering or chemical process); PROC (Process) (electrodeposit; ion beam etching for formation of structure contrasting of composites)

IT 131315-01-0, Bismuth calcium copper lead strontium oxide
 (Bi1.8Ca2Cu3Pb0.4Sr2O10)

RL: PEP (Physical, engineering or chemical process); PROC (Process) (ion beam etching for formation of structure contrasting of composites)

IT 12597-69-2, Steel, processes

RL: PEP (Physical, engineering or chemical process); PROC (Process) (oxynitrided; ion beam etching for formation of structure contrasting of composites)

REFERENCE COUNT:

THERE ARE 15 CITED REFERENCES AVAILABLE FOR THIS RECORD. ALL CITATIONS AVAILABLE IN THE RE FORMAT

L56 ANSWER 16 OF 18 HCAPLUS COPYRIGHT 2007 ACS on STN

15

ACCESSION NUMBER:

1996:241701 HCAPLUS

DOCUMENT NUMBER:

124:295554

TITLE:

SOURCE:

Manufacture of corrosion-resistant ferrous metal

composites

INVENTOR(S):
PATENT ASSIGNEE(S):

Hirai, Eiji; Matsumura, Yoshio Nippon Packaging Kk, Japan

Jpn. Kokai Tokkyo Koho, 7 pp. CODEN: JKXXAF

DOCUMENT TYPE:

Patent

LANGUAGE:

Japanese

FAMILY ACC. NUM. COUNT:

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
			,	
JP 08020877	Α	19960123	JP 1994-155986	
				199407

PRIORITY APPLN. INFO.:

JP 1994-155986

199407 07

07

AB In the process, surface of ferrous metal substrates is nitrided to form Fe N compound-containing layers, and then the layers are oxidized in aqueous baths. containing NaOH, NaNO3, and NaNO2 at 110-140° to modify at least surface parts of the layers and form Fe3O4-containing layers on the surface. Preferably, the baths further contain 1-5% Na2CO3, NaCN, Na3PO4, KNO3, Pb oxide, Na2S2O3, KCl, and/or NaCl. The composites have high wear resistance and mech. properties, e.g., fatigue strength, and homogeneous corrosion resistance.

IT 7632-05-5, Sodium phosphate

RL: NUU (Other use, unclassified); USES (Uses)
(oxidation bath components; manufacture of corrosion-resistant ferrous metal composites by nitridation and oxidation)

RN 7632-05-5' HCAPLUS

CN Phosphoric acid, sodium salt (8CI, 9CI) (CA INDEX NAME)

# ●x Na

IC ICM C23C022-62

ICS C23C008-26; C23C008-40; C23C008-80; C23C022-78; C23C028-02

CC 55-7 (Ferrous Metals and Alloys)

ST corrosion resistance ferrous metal composite;
oxidn nitridation ferrous metal surface; iron oxide
formation corrosion prevention

IT Nitridation

(manufacture of corrosion-resistant ferrous metal composites by nitridation and oxidation)

IT Iron alloy, base

RL: PEP (Physical, engineering or chemical process); TEM (Technical or engineered material use); PROC (Process); USES (Uses) (manufacture of corrosion-resistant ferrous metal composites by nitridation and oxidation)

IT 1317-61-9P, Iron oxide (Fe3O4), preparation

RL: IMF (Industrial manufacture); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses)

(formation of, surface layer components; manufacture of corrosion-resistant ferrous metal composites by nitridation and oxidation)

IT 12732-02-4, SS400, processes 37268-90-9, S45C, processes 39462-15-2, SPCC, processes

RL: PEP (Physical, engineering or chemical process); TEM (Technical

or engineered material use); PROC (Process); USES (Uses) (manufacture of corrosion-resistant ferrous metal composites by nitridation and oxidation)

143-33-9, Sodium cyanide 497-19-8, Sodium carbonate, uses IT 1310-73-2, Sodium hydroxide, uses 1335-25-7, Lead oxide 7447-40-7, Potassium chloride, uses 7631-99-4, Sodium nitrate, uses 7632-00-0, Sodium nitrite 7632-05-5, Sodium phosphate 7647-14-5, Sodium chloride, uses 7757-79-1, Potassium nitrate, uses RL: NUU (Other use, unclassified); USES (Uses) (oxidation bath components; manufacture of corrosion-resistant ferrous metal composites by nitridation and

L56 ANSWER 17 OF 18 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER:

oxidation)

1995:294612 HCAPLUS

DOCUMENT NUMBER:

122:87684

TITLE:

Manufacture of alumina-containing, aluminum phosphate-bonded metal-coated fiber-reinforced

refractories

INVENTOR(S):

Belitskus, David L.; Boland, Daniel J.; Evans, W. Thomas; Kampert, William P.; Marra, Robert

'A.; Wieserman, Larry F.

PATENT ASSIGNEE(S):

Aluminum Co. of America, USA

SOURCE:

U.S., 11 pp. Cont.-in-part of U.S. Ser. No. 393,

299.

CODEN: USXXAM

DOCUMENT TYPE:

Patent

LANGUAGE:

English

FAMILY ACC. NUM. COUNT:

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
 US 5371050	A	19941206	US 1991-680489	
03 33/1030		19941200	05 1991-000409	199104 04
US 6309994	B1	20011030	US 1989-393299	198908
PRIORITY APPLN. INFO.:			US 1989-393299 A2	_
				198908 14

- AR The method comprises dispersing Al2O3 (average particle size .ltorsim.10 μm) in an AlPO4 solution, to obtain a slurry substantially free of SiO2, impregnating a substrate of fibers coated with a metal selected from Ni, W, Mo, Pt, Cu, Ag, Au, Pd, Co, Cr, and Ti with the slurry, and curing the impregnated substrate to form fiber-reinforced AlPO4-bonded composite materials. The fiber substrate may consist of SiC fibers electroless coated with nickel. The composites have high strength at high temps.
- TΤ 7784-30-7, Aluminum phosphate
  - RL: TEM (Technical or engineered material use); USES (Uses) (binder; manufacture of aluminum phosphate-bonded metal-coated fiber-reinforced alumina refractories)
- 7784-30-7 HCAPLUS RN
- Phosphoric acid, aluminum salt (1:1) (9CI) (CA INDEX NAME) CN

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HO- b- OH
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## Al

IT

IC ICM C04B035-76
INCL 501095000
CC 57-6 (Ceramics)
IT Synthetic fibers
RL: TEM (Technical (boron nitride aluminum phos

RL: TEM (Technical or engineered material use); USES (Uses) (boron nitride, metal-coated; manufacture of aluminum phosphate-bonded metal-coated ceramic fiber-reinforced alumina refractories)

Synthetic fibers
RL: TEM (Technical or engineered material use); USES (Uses)
(silicon nitride, metal-coated; manufacture of
aluminum phosphate-bonded metal-coated ceramic fiber-reinforced
alumina refractories)

IT 7784-30-7, Aluminum phosphate:

RL: TEM (Technical or engineered material use); USES (Uses) (binder; manufacture of aluminum phosphate-bonded metal-coated fiber-reinforced alumina refractories)

L56 ANSWER 18 OF 18 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER: 1993:174136 HCAPLUS

DOCUMENT NUMBER: 118:174136

TITLE: Oxynitrided spinel structure: effect

of an oxide environment

AUTHOR(S): Goeuriot, P.; Laurent-Fievez, F.;

Goeuriot-Launay, D.; Thevenot, F.

CORPORATE SOURCE: Ec. Norm. Super. Mines Saint-Etienne,

Saint-Etienne, 42023, Fr.

SOURCE: Journal of High Temperature Chemical Processes

(1992), 1(2), 165-79

CODEN: JHTPEM; ISSN: 1240-4292

DOCUMENT TYPE: Journal LANGUAGE: French

AB Chemical and crystallog. stabilities of γ-AlON depend on the solid environment in which it is dispersed. With alumina excess, a composite material alumina-AlON is obtained by sintering-reaction between alumina and aluminum nitride. The spinel phase obtained can dissolve alumina at ≤1870°; above this temperature, it changes into the tetragonal phase. Some sintering agents were studied; Y2O3 (0.04 mol.%) is necessary to densify the composite alumina-30 volume% ALON but delays the spinel formation and enhances its decomposition by annealing at 1350-1550°. On the contrary, MgO stabilizes the spinel structure from 1350°; composites were obtained by sintering-reaction with fine microstructure.

CC 57-2 (Ceramics)

ST aluminum oxynitride alumina composite; spinel structure alumina aluminum oxynitride composite

IT Ceramic materials and wares

(aluminum oxynitride-alumina composite, spinel structure in)

IT 58875-12-0, Aluminum oxynitride (AlON)

RL: USES (Uses)

(ceramic composites, with alumina, spinel structure in)

IT 1314-36-9, Yttria, uses

RL: USES (Uses)

(in sintering, of alumina-aluminum oxynitride composites, spinel phase stabilization in relation to)

=> d 157 ibib abs hitstr hitind 1-9

L57 ANSWER 1 OF 9 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER:

2006:1091109 HCAPLUS

DOCUMENT NUMBER:

145:442396

TITLE:

Manufacture of Sm-Fe-N magnetic powder for

bonded magnet

INVENTOR(S):

Yamazaki, Minoru; Maekawa, Masaaki; Fujita,

Katsuhiro; Ikemoto, Kunio

PATENT ASSIGNEE(S): SOURCE:

Toda Kogyo Corp., Japan

Jpn. Kokai Tokkyo Koho, 20pp.

CODEN: JKXXAF

DOCUMENT TYPE:

Patent

LANGUAGE:

Japanese

FAMILY ACC. NUM. COUNT: 1

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
· · · · · · · · · · · · · · · · · · ·				
JP 2006283094	A	20061019	JP 2005-103617	200503 31
PRIORITY APPLN. INFO.:			JP 2005-103617	200503 31

- The invention relates to a Sm-Fe-N magnetic power, which contains Ca 0.001-0.2, C 0.01-0.1, and P 0.01-0.5%. The manufacture of the Sm-Fe-N magnetic powder includes mixing Fe oxide with Sm oxide, conducting reduction reaction, mixing Ca to the powder mixture for diffusion reduction reaction to obtain Sm-Fe particles, nitriding to arriving at Sm-Fe-N particles, washing, crushing in the existence of phosphoric acid, and drying. The flow characteristics of the mixture of Sm-Fe-N particles and resin for manufacture of bonded magnet are improved.
- IT 7558-79-4, Disodium hydrogenphosphate

RL: NUU (Other use, unclassified); USES (Uses)

(for manufacture of Sm-Fe-N magnetic powder for bonded magnet)

RN 7558-79-4 HCAPLUS

CN Phosphoric acid, disodium salt (8CI, 9CI) (CA INDEX NAME)

#### •2 Na

CC 56-4 (Nonferrous Metals and Alloys) Section cross-reference(s): 77

IT Nitriding

(for manufacture of Sm-Fe-N magnetic powder for bonded magnet)

IT 124-38-9, Carbon dioxide, uses 7558-79-4, Disodium

hydrogenphosphate

RL: NUU (Other use, unclassified); USES (Uses)

(for manufacture of Sm-Fe-N magnetic powder for bonded magnet)

L57 ANSWER 2 OF 9 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER:

2004:554939 HCAPLUS DOCUMENT NUMBER: 142:362860

TITLE:

SOURCE:

Preparation and optical properties of europium

or cerium doped zirconium oxynitrides

AUTHOR (S):

Gutzov, S.; Lerch, M.

CORPORATE SOURCE:

Department of Physical Chemistry, St. Kl.

Ohridski University of Sofia, Sofia, 1126, Bulg.

Dokladi na Bulgarskata Akademiya na Naukite

(2004), 57(2), 57-62 CODEN: DBANEH; ISSN: 0861-1459

PUBLISHER:

Bulgarska Akademiya na Naukite Journal

DOCUMENT TYPE:

LANGUAGE: English The nitridation of zirconia at 1900° is discussed. The incorporation of N is facilitated by the absence of aliovalent cationic dopants which is verified by simple thermodn. calcns. The effective equilibrium constant of N incorporation K 1900C

varies between 0.96 + 10-25 for rare earth or Ca doped zirconia oxynitrides and 20 + 10-25 for Zr oxynitrides. incorporated N affects the optical properties of Eu or Ce doped zirconia oxynitrides because of the presence of

absorption features at 463-495 nm in Ce-containing materials and 530-550 nm in Eu-containing ceramics. Two qual. models for explanation of the color of the oxinitrides based on color center formation and N3-

→ Zr4+ (Ce4+) charge transfer transitions are proposed.

IT 13454-71-2, Cerium phosphate

RL: PRP (Properties)

(preparation and optical properties of europium or cerium doped zirconium oxynitrides)

13454-71-2 HCAPLUS RN

CN Phosphoric acid, cerium(3+) salt (1:1) (8CI, 9CI) (CA INDEX NAME)

### • Ce(III)

CC 73-2 (Optical, Electron, and Mass Spectroscopy and Other Related Properties)

Section cross-reference(s): 75, 78

ST prepn optical property europium cerium **doped** zirconium oxynitride

IT Reflection spectra

(UV-visible; preparation and optical properties of europium or cerium doped zirconium oxynitrides)

IT Crystal vacancies

(oxygen; preparation and optical properties of europium or cerium doped zirconium oxynitrides)

IT Charge transfer transition

Color centers

Optical properties

(preparation and optical properties of europium or cerium doped zirconium oxynitrides)

IT UV and visible spectra

(reflection; preparation and optical properties of europium or cerium doped zirconium oxynitrides)

IT Nitriding

(thermal; preparation and optical properties of europium or cerium doped zirconium oxynitrides)

IT 1314-23-4P, Zirconia, properties

RL: PNU (Preparation, unclassified); PRP (Properties); PREP (Preparation)

(preparation and optical properties of europium or cerium doped zirconium oxynitrides)

IT 1308-96-9, Europium oxide 13454-71-2, Cerium phosphate 37311-45-8, Zirconium nitride oxide 189294-75-5, Cerium zirconium oxide (Ce0.07Zr0.9302) 333968-22-2, Cerium zirconium nitride oxide (Ce0.07Zr0.93N0.0701.9) 849230-43-9, Europium zirconium nitride oxide (Eu0.02Zr0.98N0.0401.88) 849230-44-0, Zirconium nitride oxide (ZrN0.1401.78) RL: PRP (Properties)

(preparation and optical properties of europium or cerium doped zirconium oxynitrides)

REFERENCE COUNT:

THERE ARE 11 CITED REFERENCES AVAILABLE FOR THIS RECORD. ALL CITATIONS AVAILABLE IN THE RE FORMAT

L57 ANSWER 3 OF 9 HCAPLUS COPYRIGHT 2007 ACS on STN

11

ACCESSION NUMBER:

2003:445952 HCAPLUS

DOCUMENT NUMBER:

139:300007

TITLE:

Initial oxynitridation of a Si(100) 2 + 1

surface by the annealing and low energy nitrogen

ion exposure

AUTHOR (S): Kim, Ki-Jeong; Ihm, Kyuwook; Jeon, Cheolho;

Hwang, Chan-Cuk; Kang, Tai-Hee; Kim, Bongsoo Pohang Accelerator Laboratory (PLS), Pohang University of Science and Technology, Pohang,

Kyungbuk, 790-784, S. Korea

Applied Surface Science (2003), 212-213, 625-629 SOURCE:

CODEN: ASUSEE; ISSN: 0169-4332

PUBLISHER: Elsevier Science B.V.

DOCUMENT TYPE: Journal English LANGUAGE:

The initial stage of the oxynitride on Si(100) 2 + 1 surface AB by the thermal annealing incorporated with the nitrogen ion was investigated using photoemission spectroscopy (PES). After growing about 20 Å thermal SiO2 layer on Si(100) 2 x 1 surface, the authors implanted nitrogen ion-with 200 eV ion energy on the surface at RT. Oxynitride and Si3N4 are found to co-exist during the thermal nitridation. PES results of Si 2p and N 1s were shown that N(-Si20) was a major component at 800° annealing. The oxygen of this oxynitride was dissolved as a volatile SiO as increasing the nitridation temperature more than 1000° and Si3N4 became a majority components. Also, N 1s core-level spectra were shifted toward the low binding energy.

CC 76-9 (Electric Phenomena)

ΙT Composition

CORPORATE SOURCE:

(XPS depth profile; of oxynitrided Si surface)

IT Annealing

> (effects on interface structure; of oxynitrided Si surface)

IT Interfacial structure

> X-ray photoelectron spectra (of oxynitrided Si surface)

REFERENCE COUNT: THERE ARE 20 CITED REFERENCES AVAILABLE 20

FOR THIS RECORD. ALL CITATIONS AVAILABLE

IN THE RE FORMAT

L57 ANSWER 4 OF 9 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER: 2002:163826 HCAPLUS

DOCUMENT NUMBER: 136:192852

Oxynitridation of Si sidewalls in shallow-trench TITLE:

insulation on integrated circuits

Leobandung, Effendi INVENTOR(S):

PATENT ASSIGNEE(S): International Business Machines Corp., USA

SOURCE: U.S., 5 pp.

CODEN: USXXAM

DOCUMENT TYPE: Patent LANGUAGE: English

FAMILY ACC. NUM. COUNT:

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
US 6352906	B1	20020305	US 2000-628864	200007

28

PRIORITY APPLN. INFO.: US 2000-628864

200007

28

.GCantelmo 10/766,385 AB The integrated-circuit wafers using shallow-trench insulation are improved when the Si walls of the active transistor area have an oxynitrided film grown on them to prevent diffusion loss of doping elements out of the transistor body, and preventing the associated shift in threshold voltage. The oxynitrided film typically contains 5-15% N, is >20 nm thick, and is grown on the etch-cleaned walls at .apprx.1000° in the presence of NO and N2O in the atmospheric IC ICM H01L021-76 INCL 438435000 76-3 (Electric Phenomena) REFERENCE COUNT: THERE ARE 4 CITED REFERENCES AVAILABLE FOR THIS RECORD. ALL CITATIONS AVAILABLE IN THE RE FORMAT L57 ANSWER 5 OF 9 HCAPLUS COPYRIGHT 2007 ACS on STN 2001:460311 HCAPLUS ACCESSION NUMBER: 135:210742 DOCUMENT NUMBER: TITLE: Synthesis of oxynitrided beta zeolite and its application in Knoevenagel reactions as solid base catalysts AUTHOR (S): Ding, Yunjie; Xiong, Jianmin; Lu, Yuan; He, Xinsheng; Lin, Liwu CORPORATE SOURCE: Dalian Institute of Chemical Physics, The Chinese Academy of Sciences, Dalian, 116023, Peop. Rep. China SOURCE: Cuihua Xuebao (2001), 22(3), 227-228 CODEN: THHPD3; ISSN: 0253-9837 Kexue Chubanshe PUBLISHER: DOCUMENT TYPE: Journal LANGUAGE: English OTHER SOURCE(S): CASREACT 135:210742  $\beta$ -Zeolite oxynitride was obtained by heating  $\beta$ -zeolite doped with 2% Ru under NH3 at 400° for up to 50 h. The nitrided zeolited successfully catalyzed the Knoevenagel reaction of PhCHO with NCCH2CO2Et. CC 23-17 (Aliphatic Compounds) IT Beta zeolites

RL: CAT (Catalyst use); SPN (Synthetic preparation); PREP (Preparation); USES (Uses)

(oxynitrided; synthesis of oxynitrided beta

zeolite and its application in Knoevenagel reactions as solid base catalysts)

IT Knoevenagel reaction catalysts

(synthesis of oxynitrided beta zeolite and its

application in Knoevenagel reactions as solid base catalysts)

IT 100-52-7, Benzaldehyde, reactions 105-56-6, Ethyl cyanoacetate RL: RCT (Reactant); RACT (Reactant or reagent)

(synthesis of oxynitrided beta zeolite and its

application in Knoevenagel reactions as solid base catalysts)

IT 2025-40-3P, Ethyl benzylidenecyanoacetate

RL: SPN (Synthetic preparation); PREP (Preparation) (synthesis of oxynitrided beta zeolite and its

application in Knoevenagel reactions as solid base catalysts)

REFERENCE COUNT: THERE ARE 5 CITED REFERENCES AVAILABLE FOR

THIS RECORD. ALL CITATIONS AVAILABLE IN

THE RE FORMAT

ANSWER 6 OF 9 HCAPLUS COPYRIGHT 2007 ACS on STN L57

ACCESSION NUMBER:

1999:271429 HCAPLUS

DOCUMENT NUMBER:

130:313941

TITLE:

Oxynitrided composition

based on an alkaline earth and tantalum or on an alkaline earth and niobium, preparation methods

and use as dyeing pigment

INVENTOR(S):

Diot, Nadege; Le Gendre, Laurent; Marchand,

Roger

PATENT ASSIGNEE(S):

Rhodia Chimie, Fr. SOURCE: PCT Int. Appl., 23 pp.

CODEN: PIXXD2

DOCUMENT TYPE:

Patent

LANGUAGE:

French

FAMILY ACC. NUM. COUNT:

PATENT INFORMATION:

PATENT NO.		DATE	APPLICATION NO.	DATE
				-
WO 9919408	A1	19990422	'WO 1998-FR2170	199810 09
RW: AT,	CA, CN, JP, K BE, CH, CY, D PT, SE		FI, FR, GB, GR, IE, IT	, LU, MC,
FR 2769612	A1	19990416	FR 1997-12769	199710 13
AU 9895444	A	19990503	AU 1998-95444	199810 09
ZA 9809320	A	19990420	ZA 1998-9320	199810 13
PRIORITY APPLN. 1	INFO.:		FR 1997-12769	A : 199710 13
			WO 1998-FR2170	W 199810 09

AB The oxynitrided pigment composition is based on an alkaline earth and at least one element selected from Ta and Nb, having a global composition A1+yM1-yO(7-3y-6x)/2N2x, where A = alkaline earth or rare earth, M = Ta or Nb or one of these two elements partially substituted by the other, and y and x are given by: 0.33  $\leq$  y  $\leq$  0.5 and 0 < x  $\leq$  (7 - 3y)/6. Another composition based on Sr and Ta and/or Nb has a global composition Sr1+yM1-yO(7-3y)/2, where M = as above, and 0.33 < y < 0.5 and the Sr/Ta ratio is preferentially between 2.16 and 2.48. The rare earth is La and the alkaline earth element is Ba or Ca, and M may be partially substituted by Ti or Zr. The components are mixed and treated at sufficiently high temperature to induce decarbonation, then treated with NH3 to form nitrides; alternatively, the elements are made to react with a nitride and the product of the reaction is then subjected to heat treatment. The pigment compns. are used to impart color to materials, e.g., plastics, paints, ceramics, glazes, paper, cosmetics, inks, mineral-based wall coverings, and surface finishes. Thus, a pigment composition was prepared from

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SrCO3 and Ta2O5 2.33 ratio by grinding in agate mortar,
heating to 900° for 2 h to effect decarbonation, then to
1350° for 9 h to obtain a precursor Sr1.4Ta0.602.9; when the
second heat treatment was carried out in NH3, the composition
was Srl.4Ta0.602.47N0.28.
ICM C09C001-02
ICS
     C08K003-00; C09D007-12; C04B033-14; D21H017-67; C09D011-00;
     A61K007-00; C14C011-00; C01G033-00; C01G035-00; C01B021-082
49-3 (Industrial Inorganic Chemicals)
Section cross-reference(s): 37
Heat treatment
Nitriding
Pigments, nonbiological
   (preparation of oxynitride compns. based on alkaline earths and
   rare earths and tantalum or niobium and use as pigments in
   materials)
Plastics, processes
RL: PEP (Physical, engineering or chemical process); PROC (Process)
   (preparation of oxynitride compns. based on alkaline earths and
   rare earths and tantalum or niobium and use as pigments in
   materials)
223581-37-1P, Strontium tantalum oxide (Sr1.4Ta0.602.9)
223581-41-7P, Strontium tantalum titanium oxide
                           223581-47-3P, Strontium tantalum titanium
(Sr1.4Ta0.54Ti0.0602.87)
oxide (Sr1.4Ta0.5Ti0.102.85)
RL: IMF (Industrial manufacture); RCT (Reactant); PREP
(Preparation); RACT (Reactant or reagent)
   (precursor, perovskite; preparation of oxynitride compns.
   based on alkaline earths and rare earths and tantalum or niobium and
   use as pigments in materials)
160716-91-6P, Calcium tantalum oxide (Cal.33Ta0.6703)
RL: IMF (Industrial manufacture); RCT (Reactant); PREP
(Preparation); RACT (Reactant or reagent)
   (precursor; preparation of oxynitride compns. based on alkaline
   earths and rare earths and tantalum or niobium and use as
   pigments in materials)
223581-13-3P, Strontium tantalum nitride oxide (Sr1.4Ta0.6N0.102.75)
223581-16-6P, Strontium tantalum nitride oxide
(Sr1.4Ta0.6N0.2802.47)
                         223581-19-9P, Strontium tantalum nitride
oxide (Srl.4Ta0.6N0.2502.52)
                               223581-21-3P, Strontium tantalum
nitride oxide (Srl.4Ta0.6N0.3702.34)
                                       223581-24-6P, Strontium
tantalum nitride oxide (Sr1.4Ta0.6N0.5102.14)
                                                223581-28-0P,
Strontium tantalum nitride oxide (Sr1.4Ta0.6N0.47O2.2)
223581-32-6P, Strontium tantalum nitride oxide (Sr1.4Ta0.6N0.701.85)
RL: IMF (Industrial manufacture); NUU (Other use, unclassified);
PREP (Preparation); USES (Uses)
   (preparation of oxynitride compns. based on alkaline earths and
   rare earths and tantalum or niobium and use as pigments in
   materials)
223581-51-9P
               223581-56-4P, Niobium strontium nitride oxide
(Nb0.67Sr1.33N0.0602.91)
                         223581-60-0P, Niobium strontium nitride
oxide (Nb0.67Sr1.33N0.202.7)
                              223581-64-4P, Niobium strontium
nitride oxide (Nb0.67Srl.33N0.3102.53)
                                         223581-68-8P, Niobium
strontium nitride oxide (Nb0.67Srl.33N0.5102.23)
RL: IMF (Industrial manufacture); RCT (Reactant); PREP
(Preparation); RACT (Reactant or reagent)
   (preparation of oxynitride compns. based on alkaline earths and
   rare earths and tantalum or niobium and use as pigments in
   materials)
9003-07-0, Eltex PHV 001
```

TC

CC

IT

IT

IT

TT

IT

IT

TT

RL: PEP (Physical, engineering or chemical process); PROC (Process) (preparation of oxynitride compns. based on alkaline earths and rare earths and tantalum or niobium and use as pigments in materials)

IT 1313-96-8, Niobium oxide (Nb2O5) 1314-61-0, Tantalum oxide (Ta2O5)
1633-05-2, Strontium carbonate (SrCO3) 7664-41-7, Ammonia,
reactions

RL: RCT (Reactant); RACT (Reactant or reagent)
(preparation of oxynitride compns. based on alkaline earths and rare earths and tantalum or niobium and use as pigments in materials)

REFERENCE COUNT:

4 THERE ARE 4 CITED REFERENCES AVAILABLE FOR THIS RECORD. ALL CITATIONS AVAILABLE IN THE RE FORMAT

L57 ANSWER 7 OF 9 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER:

1997:396655 HCAPLUS

DOCUMENT NUMBER:

127:43489

TITLE:

Manufacture of MOS transistor semiconductor

device with lightly doped drain (LDD)

structure

INVENTOR(S):

Ueda, Takashi

PATENT ASSIGNEE(S):

Sharp Corp., Japan

SOURCE:

Jpn. Kokai Tokkyo Koho, 10 pp.

CODEN: JKXXAF

DOCUMENT TYPE:

Patent

LANGUAGE:

Japanese

FAMILY ACC. NUM. COUNT: 1

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
JP 09129872	A'	19970516	JP 1995-284988	
				199511
				01
PRIORITY APPLN. INFO.:			JP 1995-284988	
				199511
				01

- AB In the manufacture, after forming a gate oxide film and a gate electrode on a Si substrate, the Si substrate is **oxynitrided** in 100% N2O or in N2O-N2 mixture atmospheric By forming the Si oxynitride film, etching of a gate electrode side wall is carried out without damaging the substrate.
- IC ICM H01L029-78

ICS H01L021-336; H01L021-318

- CC 76-3 (Electric Phenomena)
- IT MOS transistors

(in manufacture of MOS transistor semiconductor device with lightly doped drain (LDD) structure)

IT 11105-01-4P, Silicon oxynitride

RL: DEV (Device component use); IMF (Industrial manufacture); PREP (Preparation); USES (Uses)

(in manufacture of MOS transistor semiconductor device with lightly doped drain (LDD) structure)

IT 10024-97-2, Nitrogen oxide (n2o), uses

RL: NUU (Other use, unclassified); USES (Uses)

(oxynitriding gas; in manufacture of MOS transistor semiconductor device with lightly doped drain (LDD) structure)

L57 ANSWER 8 OF 9 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER: 1973:481340 HCAPLUS

DOCUMENT NUMBER: 79:81340

TITLE: High surface area nitride catalysts of boron,

aluminum, and silicon for hydrocarbon conversion

reactions

INVENTOR(S): Mattox, William Judson

PATENT ASSIGNEE(S): Esso Research and Engineering Co.

SOURCE: Brit., 10 pp. CODEN: BRXXAA

DOCUMENT TYPE: Patent LANGUAGE: English

FAMILY ACC. NUM. COUNT: 1

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE -
GB 1313174	A	19730411	GB 1970-23686	•
GD 13131,4	A	17/30411	GB 1970 23000	197005 15
NL 7007966	Α	19701204	NL 1970-7966	100000
				197006 02
PRIORITY APPLN. INFO.:			US 1969-829740	A
				196906

AB Heating mixts. of B2O3, Al, or Si with ammonia or N in acid-soluble matrix-forming material 2-9 hr at 1200-2800°F, removing the matrix by treating with dilute aqueous HCl, washing and drying gave 45-273 m2/g surface area nitride catalysts useful for petroleum cracking. An aqueous paste of 1 part B2O3 and 6 parts Ca3(PO4)2 was dried, crushed, nitrided 3 hr at 1850°F, extracted with 3 portions 3N HCl, dried, and calcined at 1000°F to give BN with a surface area 238 m2/g. Conversion of light gas oil at 430-650°F was 30.7 and 42.2% for BN catalysts with surface areas 77 and 230 m2/g, resp., compared with 19.3% for BN with surface area 11 m2/g. BN-Al2O3 and BN-SiO2-Al2O3 catalysts were also manufactured

IT 7758-87-4

RL: USES (Uses)

(boron nitride preparation in matrix of)

RN 7758-87-4 HCAPLUS

CN Phosphoric acid, calcium salt (2:3) (9CI) (CA INDEX NAME)

●3/2 Ca

IC C01B; B01J

CC 51-5 (Petroleum, Petroleum Derivatives, and Related Products) Section cross-reference(s): 49, 67

ΙT Petroleum refining catalysts

(cracking, metal nitrides, for gas oils)

IT 1309-48-4, uses and miscellaneous 7758-87-4

RL: USES (Uses)

(boron nitride preparation in matrix of)

IT 7429-90-5, reactions 7440-21-3, reactions

RL: RCT (Reactant); RACT (Reactant or reagent) (nitriding of, in calcium phosphate matrix)

ANSWER 9 OF 9 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER:

1962:461598 HCAPLUS

DOCUMENT NUMBER:

57:61598

ORIGINAL REFERENCE NO.:

57:12197d-q

TITLE:

Corrosion and electrochemical properties and

methods of protection of nitrided stainless

steel

AUTHOR (S):

Andreeva, A. G.; Gurvich, L. Ya.

SOURCE: Korroziya i Zashchita Metal., Sb. Statei (1962)

118-37

DOCUMENT TYPE: Journal LANGUAGE: Unavailable

AB cf. CA 53, 19816a. The characteristics of the 4 zones of the nitrided layer (loc. cit.) were described as follows: 1st zone, low stability in H2O and relatively neg. electrode potential, E; 2nd zone, starting about 0.01 mm. from the surface, high stability and relatively high pos. E; 3rd zone, unstable and low E; 4th zone, the core, high stability and relatively high pos. E. Nitriding under the optimum conditions, 560-600° with NH3 dissociated 20-40%, resulted in the maximum absorbed N. It reduced the thickness, but did not eliminate the 3rd zone. The final thickness of the latter was a function of the structure of the steel. The thickness varied from 50 to 80% of the total thickness of the nitrided layer in ferrite steels and from 20 to 30% in austenite steels. The 2nd zone in steel Kh18N8V2 consisted of  $\gamma$  -solid solution containing .apprx.2% Cr and up to 4% N and of ε-phase containing complex nitrides with a hexagonal crystal lattice. Treating nitrided steel 25Kh18N8V2 with boiling 10% K2Cr2007 followed by hydrophobization with a organosilicon liquid increased corrosion resistance in H2O and in humid air. Steels Kh10S2M and 2Kh13 were protected by treatment in boiling solns. containing K2Cr2O7 10, NaCl 0.5, and Na3PO4 0.3 %.

**7601-54-9**, Sodium phosphate (Na3PO4) TT

(stainless steel (nitrided) treatment with K2Cl2O7 and)

RN7601-54-9 HCAPLUS

Phosphoric acid, trisodium salt (8CI, 9CI) (CA INDEX NAME) CN

3 Na

- CC 20 (Ferrous Metals and Alloys)

The following hits were displayed by titles and only few of them seemed to be related were displayed in details.

- => d 153 ti 1-44
- L53 ANSWER 1 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI Microstructure and properties of the oxynitrided Ti-6Al-4V alloy
- L53 ANSWER 2 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI Cartridge for water purifier having pollutant adsorption and water disinfection functions and water purifier having the cartridge
- L53 ANSWER 3 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI Hydroxyapatite Pulsed Laser Deposited thin films behaviour when submitted to biological simulated tests
- L53 ANSWER 4 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI Structural and electrical characterization of oxidized, nitrided, and oxymitrided (100) GaAs surfaces
- L53 ANSWER 5 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI Metal wire-reinforced gasket with good heat resistance for an automobile exhaust pipe
- ✓L53 ANSWER 6 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
  - TI Activation of steel surface by oxynitriding
- ✓L53 ANSWER 7 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI Thin solid electrolyte battery
  - L53 ANSWER 8 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
  - TI Production of a functional coating for protection against wear, corrosion, and heat
- L53 ANSWER 9 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI Improvement of the corrosion resistance of low-pressure nitrided and post-oxidized steels by a polymer impregnation final treatment
- /L53 ANSWER 10 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
  - TI The influence of glow discharge nitriding, oxynitriding and carbonitriding on surface modification of Ti-1Al-1Mn titanium alloy
  - L53 ANSWER 11 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
  - TI Lubricants for hot working of metals
  - L53 ANSWER 12 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
  - TI A novel family of solid basic catalysts obtained by nitridation of crystalline microporous aluminosilicates and aluminophosphates
  - L53 ANSWER 13 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
  - TI Incorporation and role of nitrogen during oxynitridation of silicon studied by photoelectron spectroscopy
  - L53 ANSWER 14 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
  - TI The use of non-oxide/oxide-type ceramic materials, the ceramic products obtained, and manufacture of the ceramic products
  - L53 ANSWER 15 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN

- TI Corrosion resistance of oxynitrided layers formed on selected grades of structural steels under glow discharge conditions
- L53 ANSWER 16 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI Composition of steel surfaces and its influence on the gas nitriding mechanism
- L53 ANSWER 17 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI Agent for improving surface properties of steel tubes joined by forging
- L53 ANSWER 18 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI Lubricating mechanisms of sulfurized olefin on oxynitrided steel surface under boundary lubrication condition
- L53 ANSWER 19 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI Solid propellant based on phase-stabilized ammonium nitrate
- L53 ANSWER 20 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI Sensors for determining hydrogen dissolved in molten metals
- L53 ANSWER 21 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI Superplasticizer-based inorganic admixtures for cement
- L53 ANSWER 22 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI Increasing the corrosion resistance of gas phase nitrided low carbon steel with inhibitors
- L53 ANSWER 23 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI Corrosion resistance of **oxynitrided** layers. Experimental results
- L53 ANSWER 24 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI Pretreatment of steel surfaces before nitriding in ammonia-containing gas mixtures
- L53 ANSWER 25 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI X-ray photoelectron spectroscopy and Auger electron spectroscopy studies on the passivation behavior of plasma-nitrided low alloy steel in nitric acid
- L53 ANSWER 26 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI Thermochemical treatment of alloys
- L53 ANSWER 27 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI Plasma heat treatment of steel in a nitriding and oxynitriding atmosphere and in a mixture of air and natural gas
- L53 ANSWER 28 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI Oxymitridation process for protective finish coating on ferrous articles
- L53 ANSWER 29 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI Manufacture of silicon oxynitride electrically insulating thin films
- L53 ANSWER 30.OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI Oxymitridation of high-speed steel tools
- L53 ANSWER 31 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI Characterization of nitride-containing layers

- L53 ANSWER 32 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- Gaseous oxy-nitriding of steel 3Cr2W8V
- L53 ANSWER 33 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI Channeling analysis of thermally nitrided silicon
- L53 ANSWER 34 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- Surface analysis of an oxynitrided heat-resisting steel
- L53 ANSWER 35 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI Characterization of oxynitrided phosphate glasses
- L53 ANSWER 36 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- Nitridability of selected alloy steels TI
- L53 ANSWER 37 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- Method of surface treatment of steel workpieces TI
- L53' ANSWER 38 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- Oxynitridation of surfaces of metallic articles such as high-speed steel tools
- L53 ANSWER 39 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- ΤI Oxynitrided ferrosilicon
- L53 ANSWER 40 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- Structure and chemical composition of oxynitrided ΤI surface layers of high-speed steel
- L53 ANSWER 41 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- Coating for surfaces which contact hot glass TI
- L53 ANSWER 42 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- TI Friction materials
- L53 ANSWER 43 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- Effect of polarization on fatigue strength of steel in nitrate-nitrite melts
- L53 ANSWER 44 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN
- Oxidizing and nitriding of special steels in nitrate-nitrite medium

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L53 ANSWER 4 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER:

2003:587718 HCAPLUS

DOCUMENT NUMBER:

139:253119

TITLE:

Structural and electrical characterization of

oxidized, nitrided, and oxynitrided

(100) GaAs surfaces

AUTHOR (S):

Paul, Narayan Chandra; Nakamura, Kazuki; Takebe,

Masahide; Takemoto, Akira; Inokuma, Takao; Iiyama, Koichi; Takamiya, Saburo; Higashimine,

Koichi; Ohtsuka, Nobuo; Yonezawa, Yasuto

CORPORATE SOURCE:

Graduate School of Natural Science and

Technology, Kanazawa University, Ishikawa,

920-8667, Japan

SOURCE:

Japanese Journal of Applied Physics, Part 1: Regular Papers, Short Notes & Review Papers

(2003), 42(7A), 4264-4272

CODEN: JAPNDE

PUBLISHER: Japan Society of Applied Physics

DOCUMENT TYPE: Journal LANGUAGE: English

Oxidation by the UV & ozone process, nitridation by the nitrogen AB helicon-wave-excited plasma process, and the combination of these processes are applied to (100) GaAs wafers. An atomic force microscope, XPS, a transmission electron microscope, photoluminescence, and elec. characteristics (current-voltage and capacitance-voltage) were used to analyze the influences of these processes on the structure and composition of the surfaces and the interfaces. MIS and Schottky diodes were fabricated in order to investigate the elec. influences of these processes. The oxidation slightly disorders the GaAs surface. Nitridation of a bare surface creates about a 2-nm-thick strongly disordered layer, which strongly deteriorates the elec. and photoluminescence characteristics. Nitridation of oxidized wafers (oxynitridation) forms firm amorphous GaON layers, which contain GaN, with very flat and sharp GaON/GaAs interfaces, where crystal disorder is hardly observed. It improves the current-voltage (I-V) and capacitance-voltage (C-V) characteristics and the photoluminescence intensity. Results of the structural and the elec. characterizations qual. coincide well with each other.

CC 76-2 (Electric Phenomena)

Section cross-reference(s): 73

IT Nitriding

> (oxynitriding; structural and elec. characterization of oxidized, nitrided, and oxynitrided (100) GaAs surfaces)

IT Electric capacitance-potential relationship

Electric current-potential relationship

Luminescence

Nitriding

(structural and elec. characterization of oxidized, nitrided, and oxynitrided (100) GaAs surfaces)

IT 1303-00-0, Gallium arsenide, properties

RL: PRP (Properties)

(structural and elec. characterization of oxidized, nitrided, and oxynitrided (100) GaAs surfaces)

REFERENCE COUNT:

THERE ARE 25 CITED REFERENCES AVAILABLE FOR THIS RECORD. ALL CITATIONS AVAILABLE IN THE RE FORMAT

L53 ANSWER 6 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN

25

ACCESSION NUMBER:

2003:158588 HCAPLUS

DOCUMENT NUMBER:

138:173740

TITLE: AUTHOR(S): Activation of steel surface by oxynitriding Dong, Juan; Haase, Brigitte; Bauckhage, Klaus

CORPORATE SOURCE: TU Shandong, Peop. Rep. China

SOURCE:

HTM, Haerterei-Technische Mitteilungen (2002),

57(6), 383-388

CODEN: HTMMD5; ISSN: 0341-101X

PUBLISHER:

Carl Hanser Verlag

DOCUMENT TYPE:

Journal

LANGUAGE: German

AB In conventional gas nitriding in atmospheres containing ammonia, defective nitriding results can occur, i. e. soft spots or a

nitrided layer of insufficient or irregular thickness. These effects are due to lubricant, cutting fluid or cleaning agent residues or due to a passive oxide layer. This paper presents exptl. results showing that short-time oxynitriding is helpful to solve such problems. Phase anal. of an oxynitrided stainless steel surface shows that the outer layer consists mainly of the metal oxides Fe2O3, Fe3O4 and Cr2O3. This oxide layer is permeable for nitrogen during oxynitriding and subsequent nitriding. Activation by oxynitriding, however, has its limits which are determined by the composition and the amount of contamination, the steel's tendency of passivation as well as interactions between both factors.

CC 55-7 (Ferrous Metals and Alloys)

REFERENCE COUNT:

THERE ARE 10 CITED REFERENCES AVAILABLE FOR THIS RECORD. ALL CITATIONS AVAILABLE IN THE RE FORMAT

L53 ANSWER 7 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN

10

ACCESSION NUMBER:

2002:925553 HCAPLUS

DOCUMENT NUMBER:

138:15255

TITLE:
INVENTOR(S):

Thin solid electrolyte battery

Ito, Shuji; Iwamoto, Kazuya; Ukaji, Masaya;

Nanai, Norishige; Matsuda, Hiromu; Mino, Tatsuji; Honda, Kazuyoshi; Takai, Yoriko

PATENT ASSIGNEE(S): SOURCE:

Matsushita Electric Industrial Co., Ltd., Japan

Jpn. Kokai Tokkyo Koho, 11 pp.

CODEN: JKXXAF

DOCUMENT TYPE:

Patent

LANGUAGE:

Japanese

FAMILY ACC. NUM. COUNT: 1

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
TD 2002252650		20022206	TD 2001 154055	
JP 2002352850	. А	20021206	JP 2001-154955	200105
				24
PRIORITY APPLN. INFO.:			JP 2001-154955	24
				200105
				24

The battery has successive layers of a 1st collector, a first active mass, an electrolyte, a 2nd active mass and a 2nd collector connected to elec. conductors; where the thickness of the 1st active mass layer and the electrolyte layer is 1-20 and 1-10 µm, resp. Preferably, the collectors are orthogonal to the conductor, the electrolyte is (Li2S)x(Si S2)y(Li3PO4)z [(x+y+z)=1, x=0.3-0.8, y=0.2-0.7 and z=0.01-0.3], and the 1st or 2nd active mass is Li3-aMaN (0.2< a< 0.6; M= Co, Ni, Cu and/or Mn).

IT 10377-52-3, Lithium phosphate (Li3PO4)

RL: DEV (Device component use); USES (Uses)

(compns. of solid electrolyte for thin secondary

lithium batteries)

RN 10377-52-3 HCAPLUS

CN Phosphoric acid, trilithium salt (8CI, 9CI) (CA INDEX NAME)

●3 Li

AUTHOR(S):

IC ICM H01M010-36

ICS H01M010-36; H01M002-26; H01M002-30; H01M004-02; H01M004-58

CC 52-2 (Electrochemical, Radiational, and Thermal Energy Technology)

ST thin battery solid electrolyte lithium metal

nitride electrode

IT Battery electrolytes

(compns. of solid electrolyte for thin secondary

lithium batteries)

IT Secondary batteries

(lithium; compns. of thin secondary lithium batteries

containing solid electrolytes and lithium nitride anodes)

IT 10377-51-2, Lithium iodide (LiI) 10377-52-3, Lithium phosphate (Li3PO4) 12136-58-2, Lithium sulfide (Li2S) 13759-10-9, Silicon sulfide (SiS2) 90076-65-6, Lithium bis(trifluoromethanesulfonyl) imide 201471-17-2, Lithium phosphate sulfide thiosilicate (Li1.29(PO4)0.01S0.27(SiS3)0.36) 477704-33-9, Lithium nitride oxide phosphide (Li2.9N0.4603.3P)

RL: DEV (Device component use); USES (Uses)

(compns. of solid electrolyte for thin secondary

lithium batteries)

L53 ANSWER 10 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER: 2001:819409 HCAPLUS

DOCUMENT NUMBER: 136:105758

TITLE: The influence of glow discharge nitriding,

oxynitriding and carbonitriding on surface modification of Ti-1Al-1Mn titanium alloy Sobiecki, J. R.; Wierzchon, T.; Rudnicki, J.

CORPORATE SOURCE: Faculty of Materials Science and Engineering,

Warsaw University of Technology, Warsaw, 02-507,

Pol.

SOURCE: Vacuum (2001), 64(1), 41-46

CODEN: VACUAV; ISSN: 0042-207X

PUBLISHER: Elsevier Science Ltd.

DOCUMENT TYPE: Journal

LANGUAGE: English

AB Recent surface treatment studies show that titanium alloys should have an improved resistance to frictional wear and fatigue strength limit without any loss of their high corrosion resistance. These requirements can be satisfied by producing surface nitrided, oxynitrided and carbonitrided diffusion layers. This paper presents the results of metallog. examns., corrosion and wear resistance tests, surface chemical composition investigation, as well as rotating and bending fatigue tests. These surface treatments increase the useful properties of the titanium alloy. The influence of treatment time and the thickness of the layers on its properties are also investigated.

CC 56-7 (Nonferrous Metals and Alloys)

REFERENCE COUNT:

THERE ARE 15 CITED REFERENCES AVAILABLE 15 FOR THIS RECORD. ALL CITATIONS AVAILABLE

IN THE RE FORMAT

L53 ANSWER 15 OF 44 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER:

1998:366734 HCAPLUS

DOCUMENT NUMBER:

129:70286

TITLE:

Corrosion resistance of oxynitrided

layers formed on selected grades of structural

steels under glow discharge conditions Trojanowski, Janusz; Fleszar, Agnieszka;

Wierzchon, Tadeusz

CORPORATE SOURCE:

Instytut Mechaniki Precyzyjnej, Warsaw, Pol. Inzynieria Powierzchni (1997), (4), 12-19

CODEN: IPOWFU; ISSN: 1426-1723

PUBLISHER:

AUTHOR(S):

SOURCE:

Instytut Mechaniki Precyzyjnej

Journal Polish

DOCUMENT TYPE: LANGUAGE:

The paper presents the results of metallog., phase composition and corrosion resistance examns. of nitrided, carbonitrided, oxymitrided and oxycarbonitrided layers produced on steels. Produced compound layers have good corrosion resistance.

55-7 (Ferrous Metals and Alloys) CC

Coating materials IT

(anticorrosive; oxynitrided layers formed on structural steels under glow discharge conditions)

ΙT Nitriding

> (oxynitriding; corrosion resistance of oxynitrided layers formed on structural steels under glow discharge conditions)

IT Nitriding

> (plasma; corrosion resistance of oxynitrided layers formed on structural steels under glow discharge conditions)

37268-90-9, Steel 45, processes 39344-94-0, 40H, processes IT 157452-00-1, MM2, processes 208999-25-1, 25B Steel, processes RL: PEP (Physical, engineering or chemical process); PRP (Properties); PROC (Process)

(corrosion resistance of oxynitrided layers formed on structural steels under glow discharge conditions)